

Modified carbon-containing electrodes in stripping voltammetry of metals

Part I. Glassy carbon and carbon paste electrodes

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Abstract Papers dealing with modified electrodes made of carbon materials and composites for use in stripping voltammetry of metals have been reviewed. The review consists of two parts, of which the first considers applications of modified glassy carbon and carbon paste electrodes, while the second describes diverse modified carbon-containing composite and microscopic electrodes. Information about modifiers, electrode modification methods, conditions, and limits of detection of elements in different materials has been tabulated. The review covers 550 papers published in Russia and abroad between 1990 and the first half of 2007.

Keywords Modified electrodes · Glassy carbon · Carbon paste electrodes · Stripping Voltammetry · Metal ions determination

Introduction

Voltammetry is one of the most universal methods of electroanalytical chemistry, which is widely used as a technique for measurement of concentrations of substances and as a tool for analysis of their properties. The growing number of papers concerned with problems and urgent issues of voltammetry is indicative of the increasing interest among chemists to this method. The general status and future trends of voltammetry and electrochemical sensors are described in the reviews [1–7]. A priority line of its

development that follows from the analysis of those papers is the creation, the study and the use of new electrodes, electrochemical sensors [8], transducers, and detectors for automated, flow-through, and “field” analysis. This is because the electrochemical signal is formed by processes taking place on the electrode surface. Therefore, the condition of the electrode surface, which depends on the origin, the defect content, and the mechanical inhomogeneity of the material, determines many significant quantitative characteristics of electrochemical measurement systems. Required electrochemical properties of the electrode can be obtained if its surface is modified purposefully. Therefore, the modification and the “molecular design” of the transducer surface and the formation of grafted layers on solid surfaces constitute an actively developing new area of investigation. Problems of the chemical modification of solid surfaces, specific and regular features of the modifier attachment to various solid matrices, and examples of practical applications of chemical sensors (modified electrodes) are overviewed in the papers [9–21].

Over a period of years, the development of the voltammetric method was connected with metal, primarily mercury, electrodes. But mercury is an extremely toxic material. This element presents the first-rate hazard leading to severe poisoning and heavy diseases. For this reason, some countries (USA, Japan, EC) have declared a moratorium on the use of mercury in storage batteries, lamps, thermometers, pesticides, etc. Electrodes made of nontoxic materials also tend to smoothly force out mercury electrodes in electroanalysis. As an alternative to toxic mercury electrodes, electrodes of a nontoxic “dental” amalgam (Ag_2Hg_3 with the surplus silver; [22, 23]) have been developed and used for measurements of heavy metals. Carbon materials (CMs) possessing some attractive features [24, 25] are widely used as mercury-free current-conducting

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electrode materials. *Firstly*, depending on the CM type, the character of the electrical conduction can change from the metal to the semiconductor conduction suggesting broad potentials for a wide range of capacitive, adsorption, catalytic, and kinetic properties. *Secondly*, the carbon surface can adsorb a variety of compounds by both the nonspecific physical sorption and the specific chemisorption with a functional coating, which can be formed either under the forced action of reagents or due to the presence of native functional groups resulting from a thermomechanical treatment of the material [25, 26]. *Thirdly*, the complexation capacity of carbon materials is higher than that of metals. *Fourthly*, CMs can form strong covalent bonds with some surface modifiers favoring the development of modified electrodes. *Fifthly*, the carbon surface is electrochemically inert over a wide interval of potentials. All these features predetermine the use of diverse carbon materials in electroanalysis. Glassy carbon, pyrolytic graphite, carbon glass-ceramics, impregnated graphite, carbon fibers, filaments, cloths, gauzes, and composite materials serve as the electrode material. The properties of CM electrodes, their specific features and drawbacks, and applications in voltammetric measurements of substances are described in the Russian reviews published in 1988 and 1990 [27, 28]. The present overview covers papers published in Russia and abroad since 1990. To narrow the borders of an extensive literature stream on modified carbon-containing electrodes for the 17-year period, the current review has been restricted on a method of analysis and analyte. So, the electrodes used for metal ion determination with SV have been described only. All the papers published over this period can be divided into six main groups depending on the type of the electrode used: glassy carbon (GCE), carbon paste (CPE), carbon-containing composite (CCE), impregnated graphite (IGE), thick-film graphite-containing (TFGE) electrodes, carbon microelectrodes (CME), and their arrays (ACME). As Fig. 1 suggests, GCE is the first with

respect to the number of papers published over the 15 years. The minimum number of papers, most of which have appeared recently, are dedicated to TFGE and CME. This is due to the fact that these two groups of the electrodes represent recently emerging and vigorously developing lines of research into the use of carbon-containing electrodes.

Glassy-carbon electrodes

Glassy carbon is isotropic, is almost gas-tight, has low porosity, is very hard, is a good current conductor, and is stable in many corrosive media [25]. The adsorptivity and the reactivity of glassy carbon are low compared to those of other structured graphite materials having a hexagonal or a rhombohedral lattice. These factors account for the low sensitivity of unmodified glassy-carbon electrodes in analysis [29–34]. The detection limit of elements is reduced by increasing the electrochemical accumulation time (up to 40 min) [35–42], using additional accumulation operations, e.g., the ultrasonic extraction [43] or modifying the GCE surface.

Table 1 shows some applications of modified GCE for voltammetric measurements of inorganic ions [44–190]. Methods of the preliminary modification of the surface (ex situ) and the in-analysis modification (in situ) are widely used for the purposeful transformation of the GCE surface properties. These methods are sometimes combined to enhance the selectivity. For example, a film of a metal or a current-conducting polymer is applied to GCE and a selective organic reagent or mercury, gold, or bismuth ions, which co-precipitate with the element to be determined, are added to the solution. GC is a preferable substrate for mercury film electrodes [191]. In this case, the two-layer modification of the surface is realized by the “ex situ/in situ” scheme. On occasion, up to three modified layers each, having its specific application and certain function, are built up on the surface. For example, the layer-by-layer modification by a clay mineral, a cation-exchange cross-linked polymer and mercury [156] results in that the GCE surface forms a layer, which possesses cation-exchange properties, can form an amalgam, and separates coarse molecules or cations.

The GCE modifiers in common use are metals (mercury [44–68], gold [81–85], cadmium [87], copper [88], lead [89], platinum [90], bismuth [91–96]) and facilitating the precipitation of amalgam-forming and electropositive elements. Organic substances (OS) [107–121], macrocyclic compounds [122–126], polymers [127–131, 157–159, 165–166, 169–175], bioactive compounds [186], and nanotubes [187–190] can also serve as GCE modifiers. Different combinations of the modifiers—a metal and OS [70–80, 97–105, 106], a polymer and a metal [86, 132–147, 160–

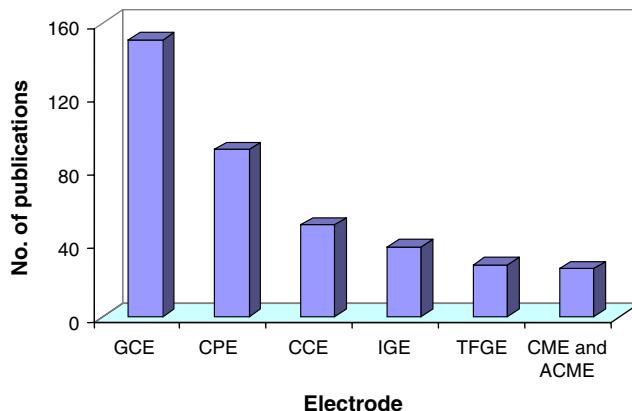


Fig. 1 Representation of papers published in 1990–2005 depending on electrode type described

Table 1 Modified glassy carbon electrodes

Modifier ^a	Manner	Analyte	Detection limit (M)	Supporting electrolyte ^b	Sweep mode ^c	Purge ^d	Sample ^e	Reference
Hg	In situ	Ni (II)	2·10 ⁻⁶	30 gL ⁻¹ H ₃ PO ₄ + 70 gL ⁻¹ Na ₂ SO ₄ + 10 gL ⁻¹ NaCl + Hg (II) (pH 4.5)	LS ASV	–	Nickel electrodeposits	[44]
Hg	In situ	Pd (II)	9·10 ⁻⁶	0.2 M KCl (pH 3) + Hg (II) (Hg:Pd≤1:10)	LS ASV	–	BGD	[45]
Hg	In situ	Fe (II, III), Mn (II)	1·10 ⁻⁶	0.5 M NaCl + Hg (II) (pH 4.0–6.0 for Mn, pH 3.5–4.0 for Fe)	LS ASV	+	Sea, drinking, service waters	[46]
Hg	In situ	Pb (II), Cd (II)	4·5·10 ⁻¹² (Cd); 1·10 ⁻⁹ (Pb)	0.01 M amm. buff. (pH 5.6) + 5·10 ⁻³ M SCN ⁻ +3·10 ⁻⁵ M Hg (II)	SQW ASV	+	Lake water	[47]
Hg	In situ	Cd (II), Pb (II), Cu (II)	10 ⁻⁹	0.1 M KNO ₃ + 0.03 M HNO ₃ + 1·10 ⁻⁴ M Hg(NO ₃) ₂	LS ASV	–	BGD	[48]
Hg	In situ	Pb (II), Cd (II), Bi (III)	5·10 ⁻⁴ % (Pb); 2·10 ⁻⁵ % (Cd); 7·10 ⁻³ % (Bi)	0.35 M KCl+0.01 M HCl+5·10 ⁻⁶ M Hg (II) (pH 2.0)	LS ASV	–	Soils, cement, rocks	[49]
Hg	In situ	Cu (II), Pb (II), Cd (II)	10 ⁻⁹ –10 ⁻¹¹	1 M HClO ₄ + 5·10 ⁻⁴ M Hg (II)	DP ASV	+	Sea waters	[50]
Hg	In situ	Cu (II), Pb (II), Cd (II)	2·10 ⁻⁵ (Pb); 7·10 ⁻⁵ (Cd); 1·6·10 ⁻⁴ (Cu)	2 M NaCl (0.5 M HCl) + 1·10 ⁻⁴ M Hg (II)	AC ASV	–	Surface, waste water	[51]
Hg	In situ	Pb (II), Cd (II), Cd (II), Pb (II)	1·10 ⁻⁹ (Pb); 1·10 ⁻¹⁰ (Cd); 1·10 ⁻⁸ (Cu); 1·10 ⁻⁸ (Zn)	1 M LiCl (0.2 M HCl) + 1·10 ⁻⁴ M Hg(NO ₃) ₂	SQW ASV	+	Surface, waste water	[52–53]
Hg	In situ	Cu (II), Pb (II), Cd (II), Zn (II)	2·10 ⁻¹⁰ (Cu); 1·10 ⁻¹⁰ (Pb); 7·10 ⁻¹¹ (Cd); 6·10 ⁻¹⁰ (Zn)	0.1 M NaAc+5·10 ⁻⁵ M Hg (II) (Cu, Cd, Pb); 0.1 M NaAc+5·10 ⁻⁵ M Hg (II) + Ga (III) (Zn)	LS ASV	–	Extract from river sediment	[54]
Hg	In situ	Cu (II), Pb (II), Cd (II), Zn (II)	6·10 ⁻¹¹ (Zn); 2·10 ⁻¹¹ (Cd); 1·10 ⁻¹¹ (Pb); 5·10 ⁻¹¹ (Cu)	0.025 M KCl (pH 3.5) + 0.3 gL ⁻¹ Hg (II)	DP ASV	+	Sea waters	[55]
Hg	Ex situ	Cu (II)	2·10 ⁻⁸	0.1 M HNO ₃	SQW ASV	–	Waters, pharmaceutical preparations	[56]
Hg	Ex situ	Pb (II)	5·10 ⁻⁹	2.5 M NaCl + 0.25 M asc. ac. + 0.24 M NaOH	DP ASV	+	Soil, air	[57]
Hg	Ex situ	Tl (I)	1·10 ⁻⁹	0.13 M EDTA+0.58 M asc. ac. + 0.7 M NaOH	DP ASV	+	Soils	[58]
Hg	Ex situ	Tl (I)	5·10 ⁻¹⁰	0.17 M EDTA + 2 mM HCl+0.03 M asc.ac	LS ASV	+	Natural waters	[59]

Table 1 (continued)

Modifier ^a	Manner	Analyte	Detection limit (M)	Supporting electrolyte ^b	Sweep mode ^c	Purge ^d	Sample ^e	Reference
Hg	Ex situ	Ba (II), Pb (II)	7·10 ⁻¹⁰ (Ba); 5·10 ⁻¹⁰ (Pb); 6·10 ⁻¹¹ (Pb); Cu (II)	0.1 M HClO ₄ or 80% ethanol + 0.1 M TBAP	DP ASV	+	BGD	[60]
	Ex situ	Pb (II), Cu (II)	2·10 ⁻¹⁰ (Cu)	0.01 M NH ₄ Ac-HCl + 1.2·10 ⁻⁴ mM NaSCN (pH 3.4)	DP ASV	–	Sea water	[61]
	Ex situ	Pb (II), Cu (II), Cd (II)	10 ⁻⁹	0.05 M HCl + 70% methanol (pH 4–6)	DP ASV	+	Foodstuffs	[62]
Hg	Ex situ	Pb (II), Cu (II), Cd (II)	10 ⁻⁷	0.1 M HNO ₃ + 5–10 gL ⁻¹ SDS	DP ASV	+	Fruit juice, wine, beer, milk powder, waste water	[63]
	Ex situ	Zn (II), Cu (II), Pb (II), Cd (II)	5·10 ⁻¹⁰ –1·10 ⁻⁹	0.1 M KNO ₃ + 2 mM HNO ₃	SQW ASV	–	Waste water	[64]
	Ex situ	Zn (II), Cu (II), Pb (II), Cd (II)	4·10 ⁻⁷ (Zn); 2.7·10 ⁻⁹ (Cd); 6·8·10 ⁻⁹ (Pb); 4·10 ⁻⁸ (Cu)	0.2 M HNO ₃	SQW ASV	–	Sweet water	[65]
Hg	Ex situ	Zn (II), Cu (II), Pb (II), Cd (II)	8·10 ⁻⁹ (Zn); 9·7·10 ⁻⁹ (Cu); 1.6·10 ⁻⁸ (Pb); 8.6·10 ⁻⁹ (Cd)	0.01 M LiCl (pH 2.9)	SQW ASV	+	Fuel	[66]
	Ex situ	Cu (II), Pb (II), Cd (II)	1 ng g ⁻¹	0.075 M NaNO ₃	LS ASV	+	Sugar, syrup	[67]
	Ex situ	Cu (II), Pb (II), Cd (II), Zn (II)	10 ⁻⁸ –10 ⁻⁹	0.1 M citric acid + 1·10 ⁻⁴ M Fe (III)	LS ASV	–	BGD, extracts from turf	[68]
Hg/Cu	Ex situ/ in situ	Se (IV)	1·10 ⁻⁹	0.1 M HClO ₄ + 1 mgL ⁻¹ Cu (II)+0.02 M NaSCN + 5·10 ⁻³ M EDTA	DP CSV	+	BGD	[69]
	In situ	Mo (VI)	5·10 ⁻⁹	0.2 M NaAc (pH 5.25) + 5·10 ⁻⁵ M Hg (II) + 10 ⁻³ M 8HXQ	DP CSV	+	Biomaterials and background objects	[70]
	In situ	Ni (II)	1.3·10 ⁻¹⁰	0.1 M KNO ₃ + 2·10 ⁻⁴ M DMG + 5·10 ⁻⁵ M Hg(NO ₃) ₂ (pH 9)	SQW CSV	–	Soils	[71]
Hg/RSH	Ex situ	Cd (II)	4·10 ⁻¹²	0.01 M NaAc (pH 3.0)	SQW CSV	+	Sea water	[72]
	In situ	Sn (IV), Pb (II)	5·10 ⁻⁹ (Pb); 4·10 ⁻⁹ (Sn)	0.1 M NaAc (pH 4.5) + 5·10 ⁻⁴ M catechol + 1 gL ⁻¹ Hg (II)	DP CSV	+	Biomaterials, foodstuffs, background objects	[73–74]

Hg/ EDA	Ex situ/ in situ	Cu (II)	0.01 M HCl + 3·10 ⁻³ M EDA	SQW ASV	–	Sea water	[75]	
Hg/ DMG	Ex situ/ in situ	Ni (II)	10 ⁻⁶	0.25 M NH ₃ + 0.25 M NH ₄ NO ₃ + 0.25 M NaSCN + 1·10 ⁻⁴ M DMG	LS CSV	–	BGD	[76]
Hg/18C6	Ex situ/ in situ	Pb (II)	1·10 ⁻⁴	0.1 M LiNO ₃ (or LiClO ₄) + 2·9·10 ⁻³ M 18C6	SQW ASV	+	BGD	[77]
Hg/ CHD or DMG	Ex situ/ in situ	Co (II), Ni (II)	1·10 ⁻⁹	30 mM HEPES + 0.1 M NaClO ₄ (pH 7.4) + CHD or DMG	DP CSV	+	Model mixtures	[78]
Hg/ CHD or DMG	Ex situ/ in situ	Co (II), Ni (II)	5·10 ⁻⁹ (Ni); 2·10 ⁻⁹ (Co)	0.1 M HEPES (pH 7.4) + 1·10 ⁻⁴ M CHD or DMG	SQW CSV	–	Biological liquids	[79]
Hg/ DMG (1), Hg/ 8HXQ (2)	Ex situ/ in situ	Ni (II) (1), Cu (II) (2)	9·10 ⁻¹⁰ (Ni); 1·10 ⁻⁹ (Cu)	0.1 M amm. buff. (pH 9) + 0.001 M DMG (Ni); 0.01 M PIPES (pH 6.8) + 5·10 ⁻⁵ M 8HXQ (Cu)	SQW CSV	–	BGD	[80]
Au	Ex situ/ Au nanoparticles	As (III)	1·6·10 ⁻⁸	HCl + Na ₂ SO ₃	DP ASV	+	Natural waters	[81]
	Ex situ	As (III)	1·3·10 ⁻¹⁰ (LS ASV); 2·10 ⁻¹⁰ (SQW ASW)	1 M HCl	LS ASV	+	River waters	[82]
Au	Ex situ	Au (III)	4·10 ⁻⁹	0.7 M HCl + 0.32 M HNO ₃	SQW ASV	–		
Au	Ex situ	CH ₃ Hg ⁺	2·10 ⁻⁸	0.1 M NaNO ₃ + 0.14 M HNO ₃	DP ASV	–	SS of gold ore	[83]
Au	Ex situ	Se (IV), Te (IV)	1·3·10 ⁻¹⁰ (Se); 1·6·10 ⁻¹⁰ (Te)	0.1 M HNO ₃	DP ASV	–	Model solution	[84]
Au/PVP	Ex situ	Hg (II)	5·10 ⁻¹⁰	0.025 M H ₂ SO ₄ + 0.05 M KCl	SQW ASV	–	Copper	[85]
Cd	In situ	Hg (II)	4·5·10 ⁻⁹	0.1 M NH ₄ Br + 10 ⁻⁸ M Cd (II)	LS ASV	–	Natural waters	[86]
Cu (1); Au (2); Se (3)	In situ	Se (IV), Au (III)	3·8·10 ⁻⁵ (Se), 1·5·10 ⁻⁵ (Au)	0.1 M HClO ₄ + 16(10) mgL ⁻¹ Cu(II) (Au(III)) (Se); 0.1 M HClO ₄ + 10 mgL ⁻¹ Se (IV) (Au)	SQW CSV	–	Natural waters	[87]
Pb	In situ	Ni (II), Co (II)	1·6·10 ⁻⁹ (Ni); 1·10 ⁻⁹ (Co)	0.1 M PIPES+5·10 ⁻³ M DMG+2·5·10 ⁻⁵ M Pb(NO ₃) ₂ (pH 6–9)	SQW CSV	–	Vitamins	[88]
Pt	nano particles	In situ	As (III)	2·8·10 ⁻⁸	LS ASV	+	SS of water and tea leaves	[89]
Bi	In situ	In (III)	10 ⁻⁸	1 M HClO ₄	LS ASV	+	Drinking water	[90]
Bi	In situ	Zn (II), Cd (II), Pb (II)	1·10 ⁻⁹ (Pb); 2·10 ⁻⁹ (Cd); 1·10 ⁻⁸ (Zn)	0.1 M NaAc (pH 4.5) + 0.1 M KBr + 200 µgL ⁻¹ Bi (III)	SQW ASV	–	Model solutions	[91]
Bi	Ex situ	Cd (II), Pb (II)	7·8·10 ⁻⁸	0.1 M acet. buff. (pH 4.75) + 2·5·10 ⁻⁴ M Ga (III)	SQW ASV	–	Model solution	[93]
Bi	Ex situ	Cd (II), Pb (II)	5·10 ⁻⁷	0.05 M NaAc	SQW ASV	–	BGD	[94]
Bi	Ex situ	Zn (II), Cd (II)	4·3·10 ⁻⁷ (Zn); 5·9·10 ⁻⁹ (Cd)	0.1 M NaAc	SQW ASV	–	BGD	[95]
Bi	Ex situ	In (III), Tl (I), Cu (II), Cd (II),	10 ⁻⁷	0.1 M NaAc (pH 4.5)	SQW ASV	–	BGD	[96]

Table 1 (continued)

Modifier ^a	Manner	Analyte	Detection limit (M)	Supporting electrolyte ^b	Sweep mode ^c	Purge ^d	Sample ^e	Reference
Bi/ CAA	Ex situ/ in situ	Pb (II), Zn (V)	2·10 ⁻⁸	0.1 M acet. buff. (pH 5.5) + 50 μM CAA + 4 mM KBrO ₄	SQW CSV	–	Groundwater	[97]
Bi/ DMG	Ex situ/ in situ	Co (II)	1·8·10 ⁻¹¹	0.0125 M PIPES + 0.002 M HEPES + 75 mgL ⁻¹ CTAB + 2·4·10 ⁻⁴ M DMG (pH 6.5)	DP CSV	+	Tea leaves, natural and drinking waters	[98–99]
Bi/ CF	Ex situ/ in situ	Cr (VI)	2·10 ⁻⁹	0.01 M PIPES + 0.2 M KCl + 0.1 mM CFA	SQW CSV	–	Tap water, soils	[100]
Bi/TEA	Ex situ/ in situ	Fe (III)	7·7·10 ⁻⁹	0.1 M NaOH + 0.01 M TEA + 5·10 ⁻³ M KBrO ₃	DP CSV	+	Standard sample of river water	[101]
Bi/ DTPA	Ex situ/ in situ	Cr (VI)	3·10 ⁻¹⁰	0.1 M NaAc (pH 4.5) + 0.25 M KNO ₃ + 1·10 ⁻⁶ M DTPA	SQW CSV	+	River waters	[102]
Bi/ DMG	Ex situ/ in situ	Co (II), Ni (II)	1·2·10 ⁻⁹ (Co); 1·7·10 ⁻⁹ (Ni)	0.2 M amm. buff. (pH 9.2) + 1·10 ⁻⁴ M DMG	SQW ASV	–	Ore, river water	[103]
Bi/ CAA	Ex situ/ in situ	Mo (VI)	2·10 ⁻⁹	0.05 M acet. buff. (pH 5.5) + 5·10 ⁻⁵ M CAA	SQW CSV	–	Sea water	[104]
Bi/cupferron	Ex situ/ in situ	U (VI)	4·10 ⁻¹⁰	0.01 M PIPES + 0.05 M KCl + 0.1 mM cupferron	SQW CSV	–	Sea water	[105]
Pb-Cu/DMG + NO ₂ [−]	In situ	Co (II)	1·10 ⁻¹¹	0.2 M (NH ₄) ₂ SO ₄ + NH ₄ OH + 0.5 M NaNO ₂ + 2·10 ⁻³ M DMG + 5·10 ⁻⁵ M Cu (II) + 1·5·10 ⁻⁵ M Pb (II) (pH 8.5)	SQW CSV	–	SS, water	[106]
8HXQ	In situ	Sn (II)	2·10 ⁻⁶	0.1 M NaAc (pH 6) + 8HXQ	SQW	+	Tooth paste, pharmaceutical preparations	[107]
HEPES	In situ	U (VI)	1·10 ⁻⁹	0.02 M HClO ₄ (pH 4) + 2·10 ⁻⁵ M HEPES	SQW CSV	+	Food stuffs, fertilizers, cement	[108]
TMAC	In situ	Al (III), Mg (II)	5·10 ⁻¹¹ (Al); 4·10 ⁻¹⁰ (Mg)	0.01 M KNO ₃ (pH 5.0) + 0.02 M TMAC	SQW ASV	+	Food stuffs, fertilizers, cement	[109]
DFO	In situ	Al (III)	2·10 ⁻⁷	0.05 M amm. buff. (pH 8.3–8.9) + (10 ⁻⁴ –10 ⁻⁵) M DFO, THMP, DHP	DP ASV	–	Natural waters, biological liquids	[110]
DDTACD	Ex situ	Au (III)	8·3·10 ⁻⁸	0.1 M NaCl + 0.01 M NaAc (pH 4)	SQW CSV	–	Geological samples	[111]
8MQN	Ex situ	Ag (I)	2·7·10 ⁻¹¹	0.1 M NaAc (pH 4.3) (accumulation), 0.1 M HNO ₃ + 0.05 M KBr (sweep)	LS ASV	–	Sea waters, rice	[112]
PAN	Ex situ	Cd (II)	5·10 ⁻¹⁰	0.1 M NaH ₂ PO ₄	LS ASV	–	Model solution	[113]
ARS	In situ	Cu (II)	1·10 ⁻⁶	0.1 M H ₃ PO ₄ + 0.1 M ARS	CV	–	BGD	[114]
Alizarin	Ex situ	Cu (II)	1·10 ⁻⁴	0.5 M Na ₂ SO ₄ (pH 4)	CV	–	BGD	[115]
BPD	In situ	Fe (II)	10 ⁻⁷	0.025 M KCl + 1 gL ⁻¹ BPD	DP AVA	+	Soils	[116]
Dithizone	Ex situ	Hg (II)	5·10 ⁻¹⁰	0.1 M KJ (pH 2)	LS ASV	–	Sea water	[117]
MAA	Ex situ	Hg (II)	4·10 ⁻²	0.1 M HNO ₃	LS ASV	–	BGD	[118]
BPD	Ex situ	Pb (II)	1·10 ⁻⁷	0.1 M NaAc (pH 4.5)	LS ASV	+	Model solutions	[119]

Humic acids	Ex situ	Fe (II), Cu (II), Ni (II)	2.0·10 ⁻⁶ (Fe); 6.0·10 ⁻⁷ (Cu); 6.0·10 ⁻⁶ (Ni)	0.1 M KHPH (Fe, Cu); 0.1 M Na ₂ SO ₄ (Ni)	SQW ASV	–	BGD	[120]
		Ex situ Ce (III) Ex situ Hg (II)	2.0·10 ⁻¹⁰ 10 ⁻¹²					
PCC KF-222	Ex situ	Hg (II)	0.1 M NaOH 0.01 M NaAc (pH 4) + 0.1 M NaClO ₄	0.1 M H ₂ SO ₄ + 0.01 M NaCl	DP ASV SQW ASV	+	SS, hair Sea and waste waters, saliva	[121] [122– 123]
		Cu (II)	2.5·10 ⁻⁸					
CA TCA TCA	Ex situ	Pb (II), Cd (II)	2.10 ⁻⁹ 2.10 ⁻⁸ (Cd); 8·10 ⁻⁹ (Pb)	0.1 M B-R (pH 4.5) 0.1 M acet. buff.	SQW ASV DP ASV DP ASV	+	Natural waters Natural waters Natural waters	[124] [125] [126]
		Pb (II)	5·10 ⁻⁹					
Nafion	Ex situ	Sn (IV)	8·10 ⁻¹⁰	0.01 M NaCl + HCl (pH 1.9) 0.01 M HClO ₄	LS CSV SQW AV	–	Standard sample TMDA- 52.2	[127] [128]
		CH ₃ Hg ⁺	4.5·10 ⁻⁸					
Nafion	Ex situ	Fe (III), Fe (II)	10 ⁻⁹	(0.03–0.3) M HCl	SQW DDV	+	Interstitial waters	[130– 131]
		Cd (II)	1·10 ⁻¹⁰					
Nafion /Hg	Ex situ	Cu (II)	1·6·10 ⁻⁶	0.01 M NaAc 0.1 M HNO ₃	LS ASV SQW ASV	+	Blood Beer	[132] [133]
		Pb (II)	1.5·10 ⁻⁸					
Nafion /Hg	Ex situ	Pb (II)	2·10 ⁻⁷	0.1 M acet. buff. (pH 3.5) 0.1 M TRIS + 0.6 M NaCl	DP ASV SQW ASV	+	Estuarial water BGD	[134] [135]
		Pb (II)	1·10 ⁻⁷					
Nafion /Hg	Ex situ/ in situ	Pb (II)	1.2·10 ⁻⁹	0.02 M KNO ₃ (pH 5) 0.1 M NaAc (pH 4.6) + 85.7 mM Hg (II)	DP ASV SQW ASV	+	Model solution Simulated saliva	[136] [137]
		Cd (II)	2·10 ⁻⁹ M (Cd); 4·10 ⁻⁹ M (Pb)					
Nafion /Hg	Ex situ	Pb (II)	3·10 ⁻¹¹ (Pb), 5·10 ⁻¹¹ (Cd)	0.1 M NaAc (pH 4.6) 0.12 M NaAc (pH 7.7)	SQW ASV	–	Waste water	[138]
		Cd (II)	9·10 ⁻⁹ (Cd), 1·10 ⁻⁷ (Pb)					
Nafion /Hg	Ex situ	Pb (II), Cu (II)	2·10 ⁻⁸ (Pb), 6·10 ⁻⁸ (Cu)	0.1 M KNO ₃ + 5 mM HNO ₃	DP ASV	–	Service waters	[142]
		Cd (II), Pb (II)	4.5·10 ⁻⁸ (Cd); 4·8·10 ⁻⁸ (Pb)					
Nafion /Hg	Ex situ	Cu (II), Pb (II), Cd (II)	1·6·10 ⁻⁸ (Cu); 4·8·10 ⁻⁹ (Pb); 8·9·10 ⁻⁹ (Cd)	0.1 M NaAc (pH 4.5) 0.1 M KNO ₃ + 0.1 M KNO ₃	DP ASV, LS CSV	+	Model solutions of fulvic acids Food stuffs	[143] [144]
		Pb (II)	4·10 ⁻¹⁰					
Nafion / Hg –Cu	Ex situ/ in situ	Pb (II), Cd (II)	4·8·10 ⁻⁸	0.1 M NaAc (pH 4.5) + 400 µg L ⁻¹ Bi (III)	SQW ASV	+	Natural waters	[145]
		Pb (II), Cd (II), Zn (II)	5·10 ⁻¹⁰ (Pb); 9·10 ⁻¹⁰ (Cd); 6·10 ⁻⁹ (Zn)					
Nafion /Bi	Ex situ/ in situ	Cd (II)	5·10 ⁻¹⁰	0.1 M acet. buff. ⁺	SQW ASV	–	Model solutions of SAS	[146]
		Zn (II)	6·10 ⁻⁹					
Nafion /Bi	Ex situ/ or ex situ	Cd (II)	9·10 ⁻¹⁰	0.1 M acet. buff. ⁺	SQW ASV	–	Tap water, urine, wine	[147]
		Zn (II)	6·10 ⁻⁹					

Table 1 (continued)

Modifier ^a	Manner	Analyte	Detection limit (M)	Supporting electrolyte ^b	Sweep mode ^c	Purge ^d	Sample ^e	Reference
Nafion + HgCl ₂	Ex situ	Pb (II), Cu (II)	5·10 ⁻⁹ (Pb); 5·10 ⁻⁸ (Cu)	0.1 M citric acid + 0.03 M Na ₂ HPO ₄ + 0.1 M KCl	LS ASV	–	Sea water	[148]
Nafion + KF-222 (1); Nafion + terpene (2)	Ex situ	Hg (II) (1), Fe (II) (2)	3·8·10 ⁻⁹ (Hg); 2·5·10 ⁻⁷ Fe (II)	0.025 M H ₂ SO ₄ + 0.1 M NaCl (Hg); 0.1 M sulphate buffer (pH 3) (Fe)	SQW ASV SQW CSV	–	BGD	[149]
Nafion + Na-DDC (1); Nafion + 18C6 (2)	Ex situ	Pb (II), Cu (II), Cd (II), Pb, Cd) (2), Hg (II)	1·10 ⁻⁸ (Hg) (1), 1·10 ⁻⁹ (Cu, Pb, Cd) (2), 5·10 ⁻¹⁰	0.1 M KNO ₃ (pH 2.0) (1), 0.1 M NaAc (2)	DP ASV	+	BGD	[150]
Nafion + tobramycin	Ex situ	Cu (II)	Acet. buff. (pH 4.6)	DP ASV	–	Water samples, analytical salts	Water samples, analytical salts	[151]
Nafion + BPD/Hg	Ex situ	Pb (II)	5·10 ⁻¹⁰	0.07 M phosphate buffer (pH 4)	SQW ASV	–	Drinking water	[152]
Nafion + DAB /Hg	Ex situ	Se (IV)	6·10 ⁻⁹	0.1 M NaClO ₄	SQW CSV	–	Natural waters	[153]
Nafion + 8HXQ /Hg	Ex situ	Te (IV)	1·6·10 ⁻⁹	0.1 M NaClO ₄ (pH 2.5) + 0.01 M EDTA	SQW CSV	+	BGD	[154]
Nafion + DMG; BPD/ Hg	Ex situ	Pb (II), Cu (II)	6·3·10 ⁻⁸ (Cu); 1·10 ⁻⁸ (Pb)	NH ₃ /NH ₄ Cl buffer (pH 9)	SQW ASV	–	Waters, urine	[155]
Nontronite /nafion /Hg	Ex situ	Cu (II)	10 ⁻⁷	0.01 M KNO ₃	SQW ASV	+	Natural waters	[156]
Tosflex	Ex situ	Cu (II)	9·4·10 ⁻⁶	0.5 M NaCl + 0.1 M NaAc (pH 5)	LS ASV	+	BGD	[157]
Tosflex	Ex situ	Hg (II)	2·10 ⁻¹¹	0.5 M NaCl + 0.01 M HCl	DP ASV	+	Natural waters	[158–159]
Tosflex /Hg	Ex situ	Bi (III)	3·10 ⁻⁹	0.5 M KCl (pH 1.4)	SQW ASV	+	Waters	[160]
Tosflex /Hg	Ex situ	Tl (III)	5·10 ⁻¹⁰	0.5 M KCl (pH 5.6)	SQW ASV	–	Model solutions	[161]
Tosflex /Hg	Ex situ	Zn (II)	1·5·10 ⁻⁹	0.02 M H ₂ SO ₄	SQW ASV	+	Model solutions	[162]
Tosflex + DAB /Hg	Ex situ	Se (IV)	1·3·10 ⁻⁹	0.1 M KCl	SQW CSV	+	Sea and sweet natural waters	[163]
Tosflex + 8HXQ /Hg	Ex situ	Te (IV)	1·6·10 ⁻⁹	0.1 M KCl (pH 3)	SQW CSV	+	Model solutions	[164]
PPG	Ex situ	Sb (III)	4·1·10 ⁻¹⁰	0.04 M NaAc (pH 5.5) (accumulation); 1.0 M HCl (sweep)	DP ASV	+	Sea water, hair	[165]
PPD	Ex situ	Hg (II)	1·10 ⁻¹⁰	0.5 M NaCl + 0.01 M HCl	DP ASV	+	Interstitial waters	[166]
PP + PDDT	Ex situ	Cu (II)	1·10 ⁻⁶	0.1 M NaAc	CV	–	Model solution	[167]
PMR	Ex situ	Hg (II)	4·4·10 ⁻¹¹	B-R buff. (pH 2.56)	LS ASV	–	Like water	[168]
CA	Ex situ	Pb (II), Cd (II)	2·10 ⁻⁷	0.1 M NaAc	DP ASV	+	Model solution	[169–170]
Nontonrite/CA	Ex situ	Cu (II)	2·7·10 ⁻⁸	amm. buff. (pH 10)	SQW ASV	–	Natural waters	[171]
OxPPh or Morin hydrate	Ex situ	Sn (II, IV), Sb (III)	5·10 ⁻⁸ (Sn); 5·10 ⁻⁸ (Sb)	0.5 M HCl + 1.5 M NaCl	LS ASV	–	Natural waters	[172–173]

polymer – EDTA	Ex situ	Pb (II), Cu (II), Hg (II)	6·10 ⁻¹⁰ (Pb); 2·10 ⁻¹⁰ (Cu); 5·10 ⁻¹⁰ (Hg)	0.2 M NaAc	SQW ASV	+	Tap water, SS of rice	[174]
	Ex situ	Ni (II), Zn (II), Cd (II), Hg (II), Cu (II), Pb (II), Co (II), Fe (II)	6·0·10 ⁻⁸ (Ni); 9·0·10 ⁻⁸ (Zn); 6·6·10 ⁻⁸ (Cd); 0·3·10 ⁻⁹ (Hg); 0·1·10 ⁻⁹ (Cu); 0·4·10 ⁻⁹ (Pb); 5·0·10 ⁻⁸ (Co); 8·0·10 ⁻⁸ (Fe)	0·2 M NaAc (pH 2·1; 2·5; 3·0; 4·1; 4·5; 4·9; 5·3; 5·7 for Ni, Zn, Cd, Hg, Cu, Pb, Co, Fe)	SQW ASV	–	BGD	[175]
	PDTT – EDTA	Ex situ						
PVP + KF222	Ex situ	Hg (II)	1·10 ⁻⁹	0·025 M H ₂ SO ₄ + 0·1 M NaCl	DP ASV	–	BGD	[176]
PVP /Hg	Ex situ	Pb (II)	1·5·10 ⁻⁹	0·025 M H ₂ SO ₄	SQW ASV	–	Subsoil waters	[177]
PVP /Hg	Ex situ	Tl (III)	5·10 ⁻¹⁰	0·01 M HNO ₃ + 0·1 M KCl	SQW ASV	–	Subsoil waters	[178]
CA/Hg	Ex situ	Pb (II)	1·9·10 ⁻⁷	0·1 M NaAc (pH 4·6)	DP ASV	+	Model solutions	[179]
PP /Hg	Ex situ	Cd (II), Pb (II)	1·10 ⁻⁶	0·1 M NaAc	SQW ASV	+	BGD	[180]
PESA /Hg	Ex situ/ in situ	Cd (II), Pb (II)	3·7·10 ⁻⁹ (Cd); 3·8·10 ⁻⁹ (Pb)	0·1 M KNO ₃ + 5 mM HNO ₃ + 0·1 mM Hg (II)	SQW ASV	–	Model solutions of SAS	[181]
PSSF /Hg; Hg /PLL-PSS	Ex situ	Pb (II), Cd (II), Cu (II)	1·2·10 ⁻¹⁰ (Pb); 9·10 ⁻¹⁰ (Cu); 6·5·10 ⁻¹⁰ (Cd)	0·5 M NaCl	SQW ASV	–	Natural waters	[182– 184]
PSSF + chabazite /Hg leaven	Ex situ	Zn (II)	5·10 ⁻⁷	0·01 M KNO ₃	SQW ASV	+	Model solutions	[185]
CNT	In situ	Au (III)	6·0·10 ⁻⁸	0·1 M HCl + 0·1 M HNO ₃	LS CSV	+	BGD	[186]
CNT	Ex situ	Hg (II)	2·10 ⁻¹⁰	0·1 M HCl + 0·02 M KJ	DP ASV	–	Lake water	[187]
	Ex situ	Cd (II), Pb (II)	6·10 ⁻⁹ (Cd); 4·10 ⁻⁹ (Pb)	0·1 M NaAc + 0·02 M KJ	DP ASV	–	Lake water	[188]
CNT + Nafion GCM-Au/MWCNT	Ex situ	Cd (II)	4·10 ⁻⁹	Acet. buff. (pH 5)	DP ASV	–	Water samples	[189]
	Ex situ	Tl (I)	2·10 ⁻⁶	10 mM HNO ₃ + 10 mM NaCl	LS ASV	–	BGD	[190]

^a CAA Chloranilic acid, 8HXQ 8-hydroxyquinoline, DMG dimethylglyoxime, RSH ω-mercaptopcarboxylic acid, EDA ethylenediamine, I8C6 18-crown-6-ether, CHD 1,2-cyclohexanedione dioxime, PVP poly(4-vinylpyridine), CAA chloranilic acid, CF cupferron, DTPA diethylene triamine pentaacetic acid, TMAC tetramethylammonium chloride, DFO diferoxamine, DDT4CD 8·9·17·18-dibenzo-1·7-dioxo-10·13·16-triazacyclooctadecane, 8MQN 8-mercaptopquinoline, PAV polyacrylonitrile, ARS alizarin red S, BPD 2,2'-bipyridyl, PCC pyrocatechol, KF-222 Cryptofix-222, MAA mercaptoacetic acid, CA calix[6]arene, TCA *p*-tert-butylthiacalix[4]arene, ACA *p*-allylcyclotriphosphazene, PES poly(estersulfonate), DDC diethyldithiocarbamate (e.g., Na, Zn), DAB 3,3'-diaminobenzidine, PPG polyppragollo, HEPES N-(2-hydroxyethyl)piperazine-N'-3-propane sulfonic acid, PPD PP derivative, PP polypyrole, PDTT (pyridyl)-5,6-diphenyl-4,4'-disulfonate-1,2,4-triazine, PMR polymethyl-red, CA cellulose acetate, OxPPh oxidized polyphenol, EDTA ethylenediaminetetraacetic acid, PDTT poly-3',4'-diamino-2,2',5',2"-terthiophen, PESA poly(ester sulfonic acid), PSSF poly(styrene sulfonate), PLL-PSS poly-L-lysine-poly(sodium 4-styrenesulfonate), CNT carbon nanotubes

^b Amm. buff. Ammonium buffer, as.ac. ascorbic acid, TBAP tetrabutylammonium perchlorate, SDS sodium dodecyl sulfate, CTAB cetyl trimethylammonium bromide, THMP 3-hydroxy-2-methyl-4H-pyran-4-one, DHP 2,3-dihydroxyquinoxidine, KHPh potassium hydrophthalate, acet. buff. acetate buffer, TRIS tris(hydroxymethyl) methylamine, FA fulvic acids, TEA-Br tetraethylammonium bromide, B-R buff. Britton-Robinson buffer

^c LS Linear sweep, ASV anodic stripping voltammetry, SQW square wave, DP differential pulse, AC alternating current, CSV cathodic stripping voltammetry, CV cyclic voltammetry, AVA anodic voltammetry, DDV double differential voltammetry, SS standard sample, SAS surface active substances

d + After, – without oxygen removal

^e BGD Supporting electrolyte, SS surface active substances

162, 177–184], a polymer and OS [149–151, 167, 174–176], a polymer, OS, and a metal [152–155, 163–164, 185]—are used for the GCE surface modification. Water-soluble OS are generally immobilized *in situ* onto the surface of a pre-activated electrode [70–71, 73–80, 97–110, 114, 116], while low-soluble OS are immobilized *ex situ* [72, 111–113, 115, 117–126, 149–155, 185]. OS are localized on either the GCE surface [107–126] or the first modifying layer of mercury [70–80], bismuth [97–105] or lead–copper [106].

For a more profound immobilization of the compounds, GCE is pre-polarized at a constant potential of (1.2–2.0) V [36, 39, 41] or undergoes multiple (up to 100) polarization cycles between 0 and +1.2 V in 0.1 M NaOH [40]. Some investigators think that, in this case, new functional groups appear on the surface [39–41], whereas others are inclined to consider the formation of an oxidized GC film [36]. Still, they are agreed that the anodic polarization radically changes the structure and the composition of the electrode surface, making it possible to fix the modifier or the measured ions on the surface through the ion exchange, the covalent bonding or the electrostatic interaction.

Polymer-coated electrodes constitute a big group of GCE [127–183]. Unique properties of the polymer surface and applications of current-conducting polymers are described in Ivaska [192]. To make a polymer film in the form of a “spin coat”, several droplets of the liquid polymer are placed in the working zone, and the electrode is spindled until the polymer film is uniform in thickness. One more method for making of a polymer film (polyaniline, polypyrogallol, polycatechol, etc.) consists in its oxidative electro-polymerization growing from a monomer solution. It was proposed to make superfine (3,000 Å) polymer films on GCE by an original method of “electrostatic spraying” [169, 170], which involves preparation of a “spray liquid” under the action of a strong electric field. For example, to apply a cellulose acetate film, a strong electric field (the voltage of 14 kV) was applied to a dielectric mixture, which was composed of cellulose acetate, acetone, and magnesium perchlorate (a porophore). The liquid was charged and was broken into tiny droplets so that a thin, uniform, and homogeneous film covered the electrode. The polymer electrode films generally have a cross-linked structure and act as molecular sieves separating coarse particles, e.g., protein molecules. Moreover, they can function as ion exchangers. For example, nafion and tosflex (fluocarbon polymers) act as a cation exchanger and an anion exchanger, respectively. Some investigators implanted analytical reagents into the structure of current-conducting polymers [148–154, 162–163, 178] providing the enhanced selectivity of the polymer film. The high selectivity to metal ions was achieved [174–175] because polymers with covalently grafted ethylenediaminetetraacetic acid (EDTA)

groups were synthesized on GCE. The response selectivity is efficiently improved by the “guest–host” interaction. Properties of crown ethers acting as host molecules for ions of guest metals were used [77, 112, 108–109, 148–149, 176] for measurements of Au (III), Hg (II), Cu (II), Pb (II), and Cd (II) ions on electrodes modified by crown-ether adsorption and a nafion film with immobilized macrocycles.

One more method for improvement of the voltammetric selectivity is the use of electrodes with monolayers of organic molecules self-organized on the electrode surface [72, 193–194]. For example, ω -carboxylic acids with hydrocarbon chains of different lengths can arrange themselves to the Langmuir palisade on gold or mercury surfaces. While possessing discrimination properties, functionalized layers can change the transport of depolarizer particles to the electrode surface not only due to different charges, but also due to the hydrophobic effect.

The pioneering studies concerned with the use of nanotube-modified GCE include the research performed by a group of Taiwan investigators [187, 188]. Such electrodes provided sufficiently low detection limits for elements. However, the introduction of these electrodes to the analytical practice requires solving the problem of structural ordering in the nanotube layer which influences the reproducibility of measurement results.

A serious problem in the use of GCE is the degradation of the modified surface showing up as the displacement of the current peak potential of the determined element, the distortion of the peak shape, and the emergence of additional peaks [195]. To make the GCE surface reproducible, it is prepared and cleaned by a great variety of methods such as mechanical polishing [108], treatment with reagents [76], electrochemical treatment by polarization at high anode potentials [36, 186], and exposure to micro-waves or ultrasound [29, 40, 131]. Mechanical polishing of the surface with abrasive diamond or Al_2O_3 powders or special polish cloths is in most common use. This surface treatment method is not only laborious and time-consuming, but what is the worst does not guarantee that the surface properties will be reproducible. This problem was attacked by development of automatic devices for cleaning of the solid electrode surface [116], but they have been used on a narrow scale because of their complexity and high cost. The original approach has been used [190] to modify GC with glassy carbon spheres covered by nanoparticles of precious metals and multiwalled nanotubes.

Carbon-paste electrodes

In 1958, Adams described a new type of the carbon-paste electrode (CPE) for voltammetry. This electrode was

Table 2 Modified carbon paste electrodes

Modifier ^a	Manner	Analyte	Detection limit (M)	Supporting electrolyte	Sweep mode ^b	Purge	Sample	Reference
Al ₂ nano	Ex situ	As (III)	3·5·10 ⁻⁹	0.1 M HNO ₃	SQW ASV	–	BGD, mineral water	[202–203]
Au	Ex situ	As (III, V)	4·10 ⁻⁸ As (III); 7·10 ⁻⁹ As (V)	1 M HClO ₄ + 0.2 M HCl + 5·10 ⁻⁶ M Au (II)	LS ASV	+	River water	[204]
Al ₂ adatoms	In situ	Au (III)	2·10 ⁻⁶	0.2 M H ₂ SO ₄	CVA	–	Model mixtures	[205]
Au	In situ	Hg (II)	2·5·10 ⁻¹⁰	0.1 M HNO ₃ + 0.02 M KCl + 5·10 ⁻⁶ M Au (II)	DP ASV	–	Drinking water	[206]
Bi	In situ	Zn (II), Pb (II), Cd (II)	1.5·10 ⁻⁸ (Pb)	0.1 M NaAc (pH 4.5) + 0.5 mgL ⁻¹ Bi (III)	SQW ASV	–	Model solutions	[207]
Bi	Ex situ	Cd (II), Pb (II)	9·10 ⁻⁹ (Cd); 4·10 ⁻⁹ (Pb)	0.2 M acet. buff. (pH 4.25)	SQW ASV or DP ASV	–	Tap, sea waters	[208–209]
Bi ₂ O ₃ or Bi	Ex situ	Zn (II), Pb (II), Cd (II)	4·4·10 ⁻⁸ (Cd); 2·4·10 ⁻⁸ (Pb)	0.1 M NaAc (pH 4.5)	DP ASV	–	Waters	[210–211]
Hg	In situ	Zn (II)	1.3·10 ⁻⁷	0.1–0.2 M amm. buff. + 2·10 ⁻⁵ M Hg(NO ₃) ₂	DP ASV	+	Drinking water	[212]
Hg	Ex situ	Cu (II), Pb (II), Cd (II)	5·10 ⁻⁹	Ammonium acetate buff. (pH 4.5)	DP ASV	–	Fish muscles and water samples	[213]
Wax + Hg oxalate	Ex situ	Cu (II), Pb (II), Cd (II), Zn (II)	3·10 ⁻⁹ (Cd)	0.1 M KCl or acet. buff. (pH 3.8)	DP ASV or LS ASV	+	Medicinal plants, tablets	[214]
Pt nanoparticles DB18C6 (1), CuO (2)	Ex situ	Cu (II)	3·9·10 ⁻⁹	0.1 M acet. buff. (pH 5.9)	LS ASV	–	Urine	[215]
	Ex situ	Pb (II)	2·10 ⁻⁹ (1); 2·5·10 ⁻⁹ (2)	0.1 M NaCl + 10 ⁻³ M 18C6 (1); 0.1 M NaCl (2)	DP ASV	+	Soil, snow, air, waters	[216]
DB18C6	Ex situ	Cu (II), Pb (II)	9·5·10 ⁻⁹ (Cu); 2·10 ⁻⁹ (Pb)	1 M NaAc (pH 5–6)	LS ASV, SQW ASV	+	Waste waters	[217]
Aza-crown compound	Ex situ	Ni (II), Co (II)	4·10 ⁻⁸ (Ni); 1·2·10 ⁻⁷ (Co)	0.1 M NaCl (accumulation); 0.1 M KOH (sweep)	DP ASV (Co + Ni); DP CSV (Ni)	–	BGD	[218]
DB18C6 and its analogs	Ex situ	Au (III), Pt (IV), Pd (II)	8·10 ⁻⁹ (Au); 3·10 ⁻⁷ (Pd)	0.1 M HCl	DP ASV	–	SS of ore	[219]
B15C5	Ex situ	Cu (II)	8·10 ⁻⁷	Water-ethanol (40%) solutions NaClO ₄ (accumulation); 0.1 M NaAc (sweep)	DP ASV AVA	–	Strong drinks BGD	[220][221]
Thiacrown compounds	Ex situ	Ag (I)	5·10 ⁻⁷	Acidified sample (accumulation); 0.1 M HCl (sweep)	DP ASV	–	Tap water	[222]
calix[4]arene	Ex situ	Cu (II)	2·10 ⁻⁸	1 M HClO ₄	ASV	–	BGD	[223–]
a-CD & b-CD	Ex situ	Pb (II),	6·3·10 ⁻⁷ (Pb); 2·0·10 ⁻⁶ (Cd);					

Table 2 (continued)

Modifier ^a	Manner	Analyte	Detection limit (M)	Supporting electrolyte	Sweep mode ^b	Purge	Sample	Reference
Zeolite	Ex situ	Cd (II), Hg (II)	5·10 ⁻⁸ (Hg)	0.05 M NaNO ₃	DP ASV	+	Dried tomayo, bakosel capsule	[225]
Silica	Ex situ	Cu (II)	1.5·10 ⁻⁸	0.1 M NH ₄ OH	LS ASV, SQW ASV	–	Subsoil, sea waters	[227– 229]
Silica modified with	Ex situ	Hg (II)	2·10 ⁻⁹	Solution pH 4–7	SQW ASV	–	Real Samples	[230]
amides AMT	Ex situ	Cu (II)	3·10 ⁻⁹	0.1 M HNO ₃	DP ASV	–	Tap water	[231]
5·10 ⁻¹⁰	Ex situ	Hg (II)	5·10 ⁻¹⁰	Sample (pH 2) (accumulation); 0.05 M KNO ₃ (sweep)	DP ASV	–	Natural waters	[232]
AMT (1); AMT/ DMG (2)	Ex situ/ in situ	Cu (II); Ni (II)	3·1·10 ⁻⁸ (Cu); 2·10 ⁻⁹ (Ni)	Ethanoic solution (accumulation); 0.1 M NH ₄ Cl + 2·5·10 ⁻³ M DMG (pH 9 for Ni) ⁱ	DP ASV (1) DP CSV (2)	–	Ethanol fuel samples	[233– 234]
thio- groups	Ex situ	Cd (II)	1·10 ⁻⁷	0.1 M phosphate buffer (pH 4) HNO ₃ (pH 3.0) (accumulation); 0.01 M KNO ₃ (sweep)	DP ASV DP ASV	+	Natural waters	[235]
Ex situ	Hg (II)	(2·5–6·5)·10 ⁻⁸	0.2 M HNO ₃	SQW ASV	–	BGD, natural water	[236– 237]	
ex situ	Pb (II); Hg (II)	2·4·10 ⁻⁹ (Pb); 1·5·10 ⁻⁸ (Hg)	pH 1(accumulation); 0.1 M HCl + 5% thiourea (sweep)	DP ASV	–	BGD	[238]	
Mercapto- groups CPA	ex situ	Hg (II)	1·10 ⁻⁶	0.05 M CH ₃ COONa (pH 5) (accumulation); 0.2 M HNO ₃ (sweep)	DP ASV	–	BGD	[239]
ex situ	U (VI)	1·10 ⁻⁷	0.2 M HNO ₃	SQW ASV	–	BGD	[240]	
Ex situ	Cd (II); Pb (II); Cu (II)	8·9·10 ⁻⁸ (Cd); 4·8·10 ⁻⁸ (Pb); 1·6·10 ⁻⁷ (Cu)	0.1 M NaClO ₄ + 1·5 M HClO ₄ (Hg, Ag, Pb); 0.1 M KCl + 1·0 M HCl (Cu)	CVA	+	BGD	[241]	
Monsil	Ex situ	Hg (II); Ag (I); Pb (II); Cu (II)	4·10 ⁻⁴ (Cu); 1·10 ⁻³ (Ag, Hg); 5·10 ⁻⁴ (Pb)	0.05 M B-R buff. (pH 3) (accumulation); 0.1 M citrate buff. (pH 3.5) (sweep)	DP ASV	–	Artificial synthetic samples	[243]
ZrPH	Ex situ	Cd (II)	2·10 ⁻⁹	0.04 M B-R buff. (accumulation); 0.1 M NaNO ₃ + 0.02 M B-R buff. (sweep)	SQW ASV DP – ASV	–	SRM 1643b (SS)	[244– 245]
Vermiculite	Ex situ	Cu (II)	5·10 ⁻⁹	0.01 M NaClO ₄	DP ASV	–	BGD	[246]
Vermiculite	Ex situ	Cu (II); Ag (I)	1·9·10 ⁻⁵ (Ag); 3·1·10 ⁻⁶ (Cu)	B-R buff. – pH 7 (Hg). pH 6 (Ag) (accumulation); B-R buff. (pH 5) + 0.05 M NaNO ₃ (sweep)	SQW ASV	–	Model solutions	[247]
Vermiculite	Ex situ	Hg (II); Ag (I)	5·7·10 ⁻⁸ (Hg); 6·3·10 ⁻⁸ (Ag)	NaAc (pH 5.5) 0.1 M HCl	DP ASV DP ASV	–	Model solutions Water, nickel metal	[248] [249]
Montmorillonite	Ex situ	Cu (II)	4·10 ⁻⁸					
Montmorillonite	Ex situ	Bi (III)	1·10 ⁻¹⁰					

Montmorillonite	Ex situ	Hg (II)	$1 \cdot 10^{-10}$	0.1 M tartaric acid 1 M KCl (pH 2) 0.05 M KCl (pH 3.2) Sample (pH 2–5) (accumulation); 0.05 M KNO ₃ (sweep)	ASV	—	BGD	[250]
	Ex situ	Hg (II)	$5 \cdot 10^{-8}$		DP ASV	—	Natural water	[251]
	Ex situ	Fe (III)	$3 \cdot 6 \cdot 10^{-6}$		DP CSV	—	BGD	[252]
	Ex situ	Hg (II)	$5 \cdot 10^{-10}$		DP ASV	—	Natural water	[253]
	TZT-HDTA-clay							
Dowex CGC241	Ex situ	Cu (II)	$6 \cdot 25 \cdot 10^{-5}$	0.1 M CH ₃ COONa (pH 6.8)	DP CSV	+	Model solutions	[254]
Dowex 50W-8X	Ex situ	Cu (II)	$1 \cdot 10^{-7}$	0.01 M KNO ₃ (accumulation); 0.1 M HCl (1 M KNO ₃) (sweep)	DP ASV	—	Waste waters	[255]
Ambertite IRS 718	Ex situ	Cd (II)	$4 \cdot 4 \cdot 10^{-8}$	1 mM amm. buff. (accumulation); 0.1 M HCl (sweep)	LS ASV	—	River waters	[256]
Dyolite GT-73	Ex situ	Hg (II); CH ₃ Hg ⁺ (I)	$2 \cdot 0 \cdot 10^{-8}$ (Hg); $9 \cdot 4 \cdot 10^{-9}$ (CH ₃ Hg ⁺)	0.1 M HCl	CV	—	River waters	[257]
Ion-exchange resin	Ex situ	Cu (II); Pb (II); Hg (II)	$2 \cdot 4 \cdot 10^{-7}$ (Cu); $1 \cdot 1 \cdot 10^{-7}$ (Pb); $5 \cdot 0 \cdot 10^{-8}$ (Hg)	0.1 M KNO ₃ + $5 \cdot 10^{-3}$ M CH ₃ COOH	DP ASV	—	Drinking water	[258]
Humic acids	Ex situ	Pd (II)	$9 \cdot 4 \cdot 10^{-8}$	0.1 M B-R buff. (pH 2.8) (accumulation); 1.0 M HCl (sweep)	LS ASV	—	Catalysts, precious metals	[259]
Humic acids	Ex situ	Pb (II); Cu (II); Hg (II)	$4 \cdot 8 \cdot 10^{-9}$ (Pb); $7 \cdot 9 \cdot 10^{-9}$ (Cu); $8 \cdot 0 \cdot 10^{-9}$ (Hg)	0.1 M KNO ₃	DP ASV	+	SRM 2670 (SS), urine	[260]
Humic acids + EDA	Ex situ	Au (III)	$5 \cdot 10^{-8}$	0.35 M HNO ₃ (accumulation); 0.8 M HCl (sweep)	DP ASV	—	Ores	[261]
Humic acids/amides	Ex situ	Hg (I; II)	$5 \cdot 10^{-8}$	0.1 M H ₂ SO ₄ (accumulation); 0.5 M H ₂ SO ₄ (sweep)	LS ASV	—	River waters	[262]
Soils	Ex situ	Cu (II)	$1 \cdot 2 \cdot 10^{-5}$	0.04 M B-R buff. + 0.1 M KNO ₃	DP ASV	+	Model solutions	[263]
HSF-Na	In situ	Ag (I)	$2 \cdot 5 \cdot 10^{-12}$	0.02 M NaAc + $8 \cdot 3 \cdot 10^{-5}$ M HSF-Na + 3 mM EDTA	DP ASV	+	Tap water	[264]
TTCP	In situ	Ag (I)	$1 \cdot 10^{-4}$	0.2 TBAP + $1 \cdot 10^{-3}$ TTCP	CV	—	BGD	[265]
BPG	In situ	Bi (III)	$5 \cdot 10^{-10}$	0.3 M HCl + $2 \cdot 0 \cdot 10^{-5}$ M BPG	ASV	+	Waters, hair	[266]
ARS	In situ	Cu (II)	$1 \cdot 6 \cdot 10^{-10}$	0.04 M B-R buff. (pH 4.56) + $3 \cdot 6 \cdot 10^{-5}$ M ARS + $1.6 \cdot 10^{-3}$ M K ₂ S ₂ O ₈	SD CSV	—	Natural water, soil	[267]
ARS	In situ	Zr (IV)	$1 \cdot 10^{-10}$	0.1 M acetic acid + 0.08 M KHP (pH 4.8) + $4 \cdot 10^{-6}$ M ARS	SD CSV	—	Ore samples	[268]
ARS + CTAB	In situ	Ce (IV)	$6 \cdot 10^{-10}$	0.1 M HAc-NaAc + 0.2 M KHP (pH 5) + $2 \cdot 10^{-6}$ M ARS + $6 \cdot 10^{-5}$ M CTAB	SD CSV	—	Cast iron samples	[269]
CTAB	In situ	Ti (IV); V (V); Mo (VI)	$2 \cdot 0 \cdot 10^{-9}$ (Ti); $1 \cdot 4 \cdot 10^{-9}$ (V); $4 \cdot 2 \cdot 10^{-10}$ (Mo)	0.01 M oxalic acid + x mM CTAB; $x=0.1$ (Ti); 0.25 (V); 0.75 (Mo)	DP ASV	+	Rock, fuel, steel	[270– 271]
CTAB, Septonex	In situ	Os (IV); Pt (IV); Ir (IV)	$5 \cdot 10^{-9}$ (Os); $1 \cdot 10^{-6}$ (Pt, Ir)	0.1 M acet. buff. + 0.15 M NaCl + $1 \cdot 10^{-5}$ M CTAB or Septonex (pH 4.5–6)	DP CSV	+	Industrial waste water	[272– 273]

Table 2 (continued)

Modifier ^a	Manner	Analyte	Detection limit (M)	Supporting electrolyte	Sweep mode ^b	Purge Sample	Reference
EDTA	In situ	Fe (III)	2·10 ⁻⁷	0.01 M KCl + 3·10 ⁻⁴ M EDTA (pH 3.0)	DP CSV	+	River and tap waters [274]
DAN	In situ	Se (IV)	1.3·10 ⁻⁷	0.1 M KCl (pH 2) + 1·10 ⁻⁴ M DAN (accumulation); 0.1 M HNO ₃ + 0.1 M KNO ₃ (sweep)	LS CSV	+	Natural, waste waters [275]
Thioridazine	In situ	Pd (II)	4.7·10 ⁻⁹	0.08 M HCl + 75 mg L ⁻¹ Thioridazine	DP ASV	+	Drinking water [276]
Mo-GGPA, Mo-SA	In situ	Ge (III); Si (IV)	0.17·10 ⁻⁸ (Ge); 0.09·10 ⁻⁸ (Si)	0.1 M citrate buff. (pH 2.5) + Mo-GGPA (Mo-SA)	DP CSV	–	Semiconductors, refined waters [277–279]
PEI	In situ	Ag (I); Hg (II); Cu (II); Pb (II); Cd (II)	0.9·10 ⁻⁶ (Ag); 1.1·10 ⁻⁶ (Hg, Cu); 8.0·10 ⁻⁷ (Pb); 8.4·10 ⁻⁷ (Cd)	0.1 M KCl (0.1 M KNO ₃) + 2% PEI (pH 3 for Pb, Cd and pH 2 for Cu)	LS ASV	–	Tap water [280–283]
IDA	Ex situ	Pb (II)	25.4 µg/kg	(pH 6) (accumulation); acet.-ammonium buff. (pH 3) (sweep)	DP ASV	–	SS of water [284]
8HXQ	Ex situ	Tl (I)	4.9·10 ⁻⁹	0.01 M B-R buff. (pH 7.96) (accumulation); 0.2 M amm. buff. (pH 10) (sweep)	DP ASV	–	USEPA SS (WP 386) [285]
2-methyl-8HXQ	Ex situ	Cu (II)	3.3·10 ⁻⁹	0.05 M KSCN+0.05 M HNO ₃ (accumulation); 0.05 M KSCN + B-R buff. (sweep)	DP ASV	+	SS [286]
2,3-Dicyano-1,4-naphthoquinone N-p-CPCHA	Ex situ	Ag (I)	5·10 ⁻⁸	0.1 M KNO ₃	LS CSV	–	BGD [287]
N-p-CPCHA	Ex situ	Cd (II)	5.5·10 ⁻⁹	0.3 M NH ₄ Cl (pH 5)	DP ASV	–	Mineral and drinking waters [288]
N-p-CPCHA	Ex situ	Pb (II)	10 ⁻⁸ – 10 ⁻⁹	0.3 M CH ₃ COONa (pH 6)	DP ASV	–	Drinking water [289]
Dithizone	Ex situ	Co (II)	3.3·10 ⁻⁷	0.2 M CH ₃ COONa (pH 6)	DP ASV	–	Vitamin B ₁₂ [290]
	Ex situ	Pb (II)	8·10 ⁻⁸	Sample pH 12 (accumulation); 0.1 M HCl (sweep)	DP ASV	–	River water [291]
Thiohydrazone BBTSC	Ex situ	Cu (II)	8·10 ⁻⁹	0.1 M HCl	CV	–	River waters [292]
	Ex situ	Hg (II)	4·10 ⁻⁸	0.01 M KNO ₃ (accumulation); 0.1 M HCl (sweep)	SQW ASV	–	River waters [293]
FTHD	Ex situ	Cd (II)	5·10 ⁻¹⁰	B-R buff. (pH 4)	DP ASV	–	Model solutions [294]
DPCO	Ex situ	Hg (II)	5·10 ⁻⁹	0.1 M KSCN (pH 2)	DP ASV	–	BGD [295]
PTL derivative	Ex situ	Cu (I)	5·10 ⁻⁹	0.5 M CH ₃ COONa (pH 6)	DP ASV	–	CO NBS 1643 [296]
PTL + nafion	Ex situ	Fe (II)	3·10 ⁻⁸	B-R buff. (pH 4.5)	DP CSV	–	Waters, SS of alloys [297]
Diacetylidioxime	Ex situ	Pb (II); Cd (II)	1·10 ⁻⁸ (Pb); 4·10 ⁻⁸ (Cd)	0.1 M NaH ₂ PO ₄	DP ASV	–	Natural waters [298]
PAN	Ex situ	Mn (II; VII)	6.9·10 ⁻⁹ Mn (II)	Phosphate-borate buffer (pH 8.7)	DP CSV	+	SS, sea water [299]

TDPTA Thiourea derivative Chelate P	Ex situ	Co (II)	$5.0 \cdot 10^{-10}$	(accumulation); amm. buff. (pH 9.4) (sweep) 0.1 M NH_4Cl (pH 4.95) 1 M NaClO_4 (pH 3.0) Sample (accumulation); 1.0 M HNO_3 (sweep)	DP CSV	+	Drinking water
	Ex situ	Ag (I)	$9.3 \cdot 10^{-8}$		LS ASV	-	BGD
	Ex situ	Cu (II)	$3 \cdot 10^{-8}$		DP ASV	-	River water
Cupron	Ex situ	Cu (II)	$4.7 \cdot 10^{-9}$	amm. buff (pH 8.5) (accumulation); 1.0 M HNO_3 (sweep)	LS ASV	-	Anodic mud, polluted water
Glyoxal derivative	Ex situ	Hg (II); Ag (I)	$1 \cdot 10^{-9}$ (Hg); $1 \cdot 10^{-10}$ (Ag)	0.1 M NaAc (pH 5) (accumulation); 0.1 M KNO_3 (sweep)	DP ASV	+	SRM 2670 (SS)
Phenylfluorone PPDA	Ex situ	Sb (III)	$8.2 \cdot 10^{-9}$	0.5 M HCl	DP ASV	+	Hair, soil
Zn-DDC	Ex situ	Pb (II)	$1 \cdot 10^{-9}$	0.1 M KNO_3 (accumulation); 0.1 M HCl (sweep)	DP ASV	-	Sea waters
DMG + glycerol	Ex situ	Hg (II)	$8 \cdot 10^{-10}$	0.1 M HClO_4 (accumulation); 0.1 M $\text{KSCN} + 0.01 \text{ M } \text{HClO}_4$ (sweep)	DP ASV	+	USEPA SS (WP 386), urine
TBP	Ex situ	Hg (II); Ni (II); Co (II); Pd (II)	10^{-8}	Buffer (pH 4.8)	CSV	Rice, tea, hair	[308]
Morin Lichen	Ex situ	Zn (II); Ga (III)	$2 \cdot 10^{-6}$	7 M HCl (accumulation); 0.5 M ethanolamine + 0.2 M TEA-Br (sweep)	CVA	-	Model mixtures
Lichen	Ex situ	Zr (IV)	$1 \cdot 10^{-8}$	2.2 M HCl	SD ASV	-	Ore
	Ex situ	Pb (II); Cu (II)	$2 \cdot 10^{-5}$ (Pb)	0.02 M NaAc (Cu)	DP ASV	+	-
	Ex situ	Pb (II)	$1 \cdot 10^{-8}$	NaAc with ionic force 0.01 (accumulation); NaAc with ionic force 0.7 (sweep)	DP ASV	-	Natural and drinking waters

For other abbreviations see Table 1.

^a *HSF-Na* Sodium heptyl sulfonate, *TTCP* 2,5,8-trithio[9]-*m*-cyclophane, *BPG* bromopyrogallol, *DAN* diamononaphthalene, *Mo-GGPA* molybdenum-germanium heteropolyacid, *Mo-SA* molybdsilicic acid, *PEI* polyethyleneimine, *ID4* iminodiacetate, *DB18C6* dibenzo-18-crown-5, α -*CD* and β -*CD* α - and β -cyclodextrins, *CPA* carbamoyl phosphonic acid, *AMT* 2-aminothiazole, *ZrPH* zirconium biphthalate, *TZT-HDT4-clay* 2-thiazoline-2-thiol-hexadecyltrimethylammonium-clay, *N-p-CPCHA* chlorophenyl cinnamohydroxamic acid, *BBTSC* benzylbisthiocarbazole, *FTHD* 1-furylthioureas, *DPCO* diphenylcarbazone, *PTL* 1,10-phenanthroline, *TDPTA* 2,4,6-tri(3,5-dimethylpyrazoyl)-1,3,5-triazine, *PPDA* poly-*n*-phenylenediamine, *TBP* tri-*n*-butylphosphate

^b CVA Cathodic voltammetry, SD second derivative of voltammogram

conceived because despite good performance capabilities of mercury electrodes with respect to the adsorptive concentration of inorganic ions [196–198], they have some limitations at positive potential range, while many solid electrodes, which are operable over a wide interval of potentials, cannot selectively sorb the required component of the system. Adams' idea was not overlooked by other investigators, and in 1964, Kuwana et al. performed research making the first contribution to the advancement of chemically modified carbon-paste electrodes, which are described in the reviews [199–201].

CPE is made of a homogenized paste of fine-dispersed coal and a water-immiscible binding liquid. Paraffin, petrolatum, or polychlorotrifluoroethylene oils, silicon fluid, dioctylphthalate, α -bromnaphthalene, tricresyl phosphate, and other materials can be used as the binding liquid. Two types of CPE pastes are available: dry (0.3–0.5 ml of the binding liquid per 1 g of the carbon powder) and wet (0.5–0.9 ml of the binding liquid per 1 g of the carbon powder) pastes. CPE can bear a high residual current caused by oxygen admixed to the paste with carbon powder particles. The residual current can be eliminated if the preheated carbon powder is mixed with wax, paraffin, or petrolatum oil in the nitrogen atmosphere or a lipophilic paste fluid (tricresyl phosphate) is added. The detection limit (LOD) of many inorganic and organic substances on CPE generally is $1 \cdot 10^{-9}$ M. LOD is frequently decreased by activation of the electrode at high negative or positive potentials. The anode activation of the electrode is most efficient because interfering organic substances can be removed from the surface in this case. Sometimes the electrode is "shaken up" through the cyclic polarization between large negative and positive potentials.

When compared to other carbon-containing electrodes, CPE has a well-developed surface with a high adsorptivity of various substances. This property of CPE is used successfully in voltammetry for the modification and the adsorptive accumulation of substances to be measured. A modifier can be immobilized on CPE by several means including sorption, covalent binding, dissolution of a lipophilic modifier in the paste fluid, and direct mixing with the carbon paste. Direct mixing of a modifier with the paste is used most frequently. This modification procedure is very simple: a modifier is added to the paste in the dry form or diluted in a small amount of an organic solvent making the paste more homogeneous. Other methods of the modifier immobilization are used least often. The depolarizer is concentrated on the modified CPE surface through adsorption, chemical, or electrostatic interaction of the element to be measured and the modifier. CPE is modified by various organic substances such as aromatic oxycarboxylic acids, aromatic amine and diimine compounds, azocompounds, dyes, thiocompounds, triazines, and quino-

lines. In addition to the main hydrocarbon chain, molecules of these organic compounds include nitrogen, sulfur, and oxygen atoms, aromatic and aliphatic cycles containing unbound π -electrons, which can interact, on one hand, with the electrode surface and, on the other hand, with the analyte ensuring a high surface adsorption and strong binding to the substance to be determined.

Every so often, the analyte is concentrated on modified CPE with the circuit open using extraction, sorption, ion exchange, and formation of ion pairs. The measurement stage can be accomplished in another electrolyte. As the electrolyte is replaced, it is possible to optimize the measurement parameters (pH, the ionic force, and the potential) and eliminate the interference of other components of the test solution. Dependences of the current peak of the element to be determined on the concentration and the accumulation time on CPE are flattened-out curves because all functional groups of the modifier are saturated.

Table 2 gives examples of specific applications of modified CPE for the voltammetric determination of metal ions [202–312]. Sometimes CPE is modified by films of metals and their oxides [202–213, 215–216]. The electrode is modified most frequently by crown compounds [216–221], calixarenes [222], cyclodextrins [223–225], non-functionalized and functionalized silica [226–243], clay minerals (vermiculite and montmorillonite) [244–253], ion exchangers in the form of artificial resins [254–258 258–262], natural humic acids and soils [259–263], organic [264–310], and bioactive compounds [311–312].

Electrodes based on silica with self-organizing monolayers, for example, mesoporous silica modified by acetamide of the phosphonic acid provide accumulation and measurement of Cu, Pb, Cd, and U [240–241]. CPE modified by biocatalysts, which are constituents of α - and β -cyclodextrins [223–225] or natural lichens [311–312] are used for measurement of ions of heavy metals.

Solid depolarizers can be studied after their direct infusion to CPE, which has been called the carbon-paste electroactive electrode (CPEE). The CPEE methodology was recognized to be also suitable for insoluble electroactive compounds. The first studies of metals, metal oxides, chalcogenides, salts, and other compounds by CPEE methodology were reviewed by Brainina et al. [313]. Electrochemical transformations taking place on CPEE provide information about the electrochemical activity of solid compounds, their stoichiometry, the oxidized state of elements, the morphology (the size and the shape of particles, crystal defects), the catalytic activity, etc. The CPEE methodology significantly increased the scope of electrochemistry to poorly conducting and insoluble solids. CPEE is used to analyze lead sulfides, magnetite, oxides of silver, tin, copper, and iron, bromides of rare-earth elements, nickel-containing compounds and other solids,

e.g., ceramics and glasses [314–318]. A comprehensive review [319] is dedicated to the electrochemical analysis of solids.

Conclusion

Considering the above numerous examples of the electrochemical study and determination of various elements and compounds, it can be concluded that the modification of the surface of solid electrodes by a variety of methods and substances considerably extends the capabilities of voltammetry and ensures a highly sensitive and selective determination of a wide range of elements traces.

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References

- Maystrenko VN, Gusakov VN, Sangalov EYU (1995) *J Anal Chem* 50:582
- Vjaslev MR (1995) *J Anal Chem* 50:723
- Budnikov GK (1996) *J Anal Chem* 51:374
- Wang J, Tian B (1999) *Anal Chim Acta* 385:429
- Brainina KHZ (2001) *J Anal Chem* 56:344
- Bakker E (2004) *Anal Chem* 76:3285
- Bakker E, Qin Y (2006) *Anal Chem* 78:3965
- Vlasov YUG (1992) *J Anal Chem* 47:114
- Zolotov YUA (1990) *J Anal Chem* 45:1255
- Mjasoyedov BF, Davydov AV (1990) *J Anal Chem* 45:1259
- Brainina KHZ (1995) *Anal Chim Acta* 305:146
- Tarasevich MR, Bogdanovskaja VA, Gegeshidze LV (1999) *J Anal Chem* 54:966
- Budnikov G, Murinov Yu, Maystrenko V (1994) Voltammetry with modified and ultramicroelectrodes. Nauka, Moscow
- Bakker E (2004) *Anal Chem* 76:3285
- Bakker E, Telting-Diaz M (2002) *Anal Chem* 74:2781
- Dong S, Wang Y (1989) *Electroanalysis* 1:99
- Wang J (1991) *Electroanalysis* 3:255
- Downard AJ (2000) *Electroanalysis* 12:1085
- Walcarus A (2001) *Electroanalysis* 13:701
- Navratilova Z, Kula P (2003) *Electroanalysis* 15:837
- Zen JM, Kumar AS, Tsai DM (2003) *Electroanalysis* 15:1073
- Yosypchuk B, Novothý L (2002) *Electroanalysis* 14:1733
- Mikkelsen Ø, Schröder KH (2003) *Electroanalysis* 15:679
- McCreery RL (1999) Electrochemical properties of carbon surfaces. In: Wieckowski A (ed) *Interfacial electrochemistry. Theory, experiment and applications*. Dekker, New York, pp 631–647
- Tarasevich MR (1984) *Electrochemistry of carbon materials*. Nauka, Moscow
- Lisichkin GV (2003) *Chemistry of graft surface compounds*. Phismatlit, Moscow
- Khanina RM, Tataurov VP, Brainina KHZ (1988) *Zavodsk Lab* 54/2:1
- Kaplin AA, Pikula NP, Neyman E (1990) *J Anal Chem* 45:2086
- Hardcastle JL, Murcott GG, Compton RG (2000) *Electroanalysis* 12:559
- Kilimnik AB, Abakumova EA, Churikov AV (1998) *Zavodsk Lab* 64/4:12
- Lowinson D, Bertotti M (2002) *Electroanalysis* 14:619
- Viter IP, Kamenev AI (1997) *J Anal Chem* 52:1180
- Fofanova TM, Bulantseva VN, Karbainov Y (1995) *J Anal Chem* 50:283
- Tomcik P, Banks CE, Compton RG (2003) *Electroanalysis* 15:1661
- Staden JF, Matoetoe M (1997) *Fresenius J Anal Chem* 357:624
- Shiu K, Shi K (1998) *Electroanalysis* 10:959
- Scholz F, Meyer S (1994) *Naturwissenschaften* 81:450F
- Meyer S, Scholz F, Trittler R (1996) *Fresenius J Anal Chem* 356:247
- Roitz JS, Bruland KW (1997) *Anal Chim Acta* 344:175
- Zhang J, Di F (2003) *Talanta* 60:31
- El-Maali NA, El-Hady DA (1998) *Anal Chim Acta* 370:239
- Staden JF, Matoetoe MC (1998) *Anal Chim Acta* 376:325
- Compton RG, Eclund JC, Marken F (1997) *Electroanalysis* 9:509
- Nadezhina LS, Konstantinova SA, Filanovsky BK (1991) *J Anal Chem* 46:2442
- Nadezhina LS, Lobnova OA, Pankina IA (1998) *J Anal Chem* 53:171
- Zgadova VA, Nemova VV, Nemov VA (1987) *J Anal Chem* 62:1644
- Fischer E, Berg CMG (1999) *Anal Chim Acta* 385:273
- Wu HP (1996) *Anal Chem* 68:1639
- Nesterina EM, Bebeschko GI (2002) *Zavodsk Lab* 68:13
- Sun YC, Tu YL, Mierzwa J (1998) *Fresenius J Anal Chem* 360:550
- Petrov SI, Ivanova ZHV (2000) *J Anal Chem* 55:1224
- Petrov SI, Kukhnikova LV, Ivanova ZHV (1998) *Zavodsk Lab* 64/9:13
- Petrov SI, Kukhnikova LV, Ivanova ZHV (1998) *Zavodsk Lab* 64/6:13
- Silva CL, Masini JC (2000) *Fresenius J Anal Chem* 367:284
- Lee JD, Lo JM (1994) *Anal Chim Acta* 287:259
- Economou A, Fielden PR (1996) *Analyst* 121:1903
- Ashley K (1995) *Electroanalysis* 7:1189
- Laar C, Reinke L, Simon J (1994) *Fresenius J Anal Chem* 349:692
- Kozina SA (2003) *J Anal Chem* 58:1067
- Woolver CA, Dewald HD (2001) *Electroanalysis* 13:309
- Monterroso SCC, Carapuça HM, Simão JEJ et al (2004) *Anal Chim Acta* 503:203
- Wahdat F, Hinkel S, Neeb R (1995) *Fresenius J Anal Chem* 352:393
- Hoyer B, Jensen N (2004) *Analyst* 129:751
- Brett CMA, Brett AMO, Tugulea L (1996) *Anal Chim Acta* 322:151
- Martinotti W, Queirazza G, Guarinoni A, Mori G (1995) *Anal Chim Acta* 305:183
- Oliveira MF, Saczk AA, Okumura LL, Fernandes AP, Moraes M, Stradiotto NR (2004) *Anal Bioanal Chem* 380:135
- Oliveira MF, Khoulif Z, Jambon C, Chatelut M (1993) *Electroanalysis* 5:339
- Daniel L, Zakhrova EA, Goloskova NB, Schelkovnikova VV (1992) *J Anal Chem* 47:448
- Lange B, Scholz F (1997) *Fresenius J Anal Chem* 358:736

70. Adeloji SBO, Pablo F (1995) *Electroanalysis* 7:476
71. Rocha MM, Neto MM, Yorres MO, Varennes A (1997) *Electroanalysis* 9:145
72. Turyan I, Mandler D (1994) *Anal Chem* 66:58
73. Adeloji SBO, Pablo F (1992) *Anal Chim Acta* 270:143
74. Adeloji SBO, Pablo F (1995) *Electroanalysis* 7:750
75. Sanchez-Misiego A, Garcia-Moncó Carra R, Zirino A (1996) *Electroanalysis* 8:534
76. Diederich H, Meyer S, Scholz F (1994) *Fresenius J Anal Chem* 349:670
77. Geary CD, Weber SG (2003) *Anal Chem* 75:6560
78. Brett CMA, Brett AMO, Pereira JLC (1991) *Electroanalysis* 3:683
79. Brett CMA, Brett AMO, Tugulea L (1996) *Electroanalysis* 8:639
80. Economou A, Fielden PR (1993) *Anal Chim Acta* 273:27
81. Rasul SB, Munir AKM, Hossain ZA et al (2002) *Talanta* 58:33
82. Dai X, Nekrassova O, Hyde ME, Compton RG (2004) *Anal Chem* 76:5924
83. Korolczuk M (1996) *Fresenius J Anal Chem* 356:480
84. Ireland-Ripert J, Bermond A, Ducauze C (1982) *Anal Chim Acta* 143:249
85. Hamlton TW, Ellis J (1979) *Anal Chim Acta* 110:87
86. Zen IJ, Chung MJ (1995) *Anal Chem* 67:3571
87. Viter IP, Kamenev AI (1993) *J Anal Chem* 48:1197
88. Fijatek Z, Łozak A, Sarna K (1998) *Electroanalysis* 10:846
89. Korolczuk M, Tyszcuk K, Grabarczyk M (2005) *Electrochim commun* 7:1185
90. Dai X, Compton RG (2006) *Analyst* 131:516
91. Charalambous A, Economou A (2005) *Anal Chim Acta* 547:53
92. Kefala G, Economou A, Voulgaropoulos A, Sofoniou M (2003) *Talanta* 61:603
93. Prior C, Lenehan CE, Walker GS (2006) *Electroanalysis* 18:2486
94. Boteelho CMS, Boaventura RAR, Goncalves MLS (2002) *Electroanalysis* 14:1713
95. Banks CE, Kruusma J, Hyde ME et al (2004) *Anal Bioanal Chem* 379:277
96. Wang J, Lu J, Kirgöz ÜA et al (2001) *Anal Chim Acta* 434:29
97. Wang J, Lu D, Hongngamdee S, Lin Y et al (2006) *Talanta* 69:914
98. Krolicka A, Bobrowski A, Kalcher K et al (2003) *Electroanalysis* 15:1859
99. Korolczuk M, Moroziewicz A, Grabarczyk M (2005) *Anal Bional Chem* 382:1678
100. Chatzitheodorou E, Economou A, Voulgaropoulos A (2004) *Electroanalysis* 16:1745
101. Bobrowski A, Nowak K, Zarebski J (2005) *Anal Bional Chem* 382:1691
102. Lin L, Lawrence N, Thongngamdee S et al (2005) *Talanta* 65:144
103. Morfobos M, Economou A, Voulgaropoulos A (2004) *Anal Chim Acta* 519:57
104. Wang J, Thongngamdee S, Lu D (2006) *Electroanalysis* 18:59
105. Kefala G, Economou A, Voulgaropoulos A (2006) *Electroanalysis* 18:223
106. Grabarczyk M, Tyszcuk K, Korolczuk M (2006) *Electroanalysis* 18:70
107. Yang Z, Alafandy M, Boutakhrit K et al (1996) *Electroanalysis* 8:25
108. El-Maali NA, El-Hady DA (1999) *Electroanalysis* 11:201
109. El-Maali NA, El-Hady DA, El-Hamid AM, Seliem MM (2000) *Anal Chim Acta* 417:65
110. Di J, Zhang F, Zhang M, Bi S (2004) *Electroanalysis* 16:644
111. Guo SH, Khoo SB (1999) *Electroanalysis* 11:891
112. Turyan I, Mandler D (1994) *Fresenius J Anal Chem* 349:491
113. Hu S, Wu K, Yi H et al (2001) *Fresenius J Anal Chem* 370:101
114. Shiu KK, Song FY (1998) *Elecrtoanalysis* 10:256
115. Komura T, Isogai S, Yamaguchi T et al (2000) *J Electroanal Chem* 490:70
116. Li Q, Bi S, Ji G (2003) *J Electroanal Chem* 560:19
117. Huang W, Zhang S (2002) *Anal Sci* 18:187
118. Zbou Y, Zbu G, Wang E (1994) *Electroanalysis* 6:903
119. Wagner K, Strojek JW, Koziel K (2001) *Anal Chim Acta* 447:11
120. García CD, Ortiz PI (2003) *Talanta* 61:547
121. Khoo SB, Zhu J (1999) *Electroanalysis* 11:546
122. Turyan I, Mandler D (1994) *Electroanalysis* 6:838
123. Turyan I, Mandler D (1993) *Nature. Scientific correspondence* 362:703
124. Lu J, He X, Zeng X et al (2003) *Talanta* 59:553
125. Zheng H, Dong H, Yan Z et al (2006) *Electroanalysis* 18:2115
126. Zheng H, Yan Z, Dong H, Ye B (2007) *Sens Actuators B: Chemical* 120:603
127. Crowley K, Cassidy J (2002) *Electroanalysis* 14:1077
128. Yang S, Tian H, Wang D, Tang Y (1995) *J Electroanal Chem* 383:31
129. Moretto LM, Ugo P, Lacasse R et al (1999) *Electrochemical Society Proceedings. Proceedings of the symposium on “Chemical and biological sensors and analytical electrochemical methods”* 97:255
130. Ugo P, Moretto LM, Rudello A et al (2001) *Electroanalysis* 13:661
131. Ugo P, Moretto LM, Boni AD et al (2002) *Anal Chim Acta* 474:147
132. Kruusma J, Nei L, Hardcastle JL et al (2004) *Electroanalysis* 16:399
133. Gutierrez CA, Hardcastle JL, Ball JC, Compton RG (1999) *Analyst* 124:1053
134. Hurst MP, Bruland KW (2005) *Anal Chim Acta* 546:68
135. Dam MER, Scroder KH (1996) *Electroanalysis* 8:1040
136. Capelo S, Mota AM, Gonçalves MLS (1995) *Electroanalysis* 7:563
137. West CE, Hardcastle JL, Compton RG (2002) *Electroanalysis* 14:1470
138. Brett CMA, Brett AMO, Matysik FM et al (1996) *Talanta* 43:2015
139. Matysik FM, Matysik S, Brett AMO, Brett CMA (1997) *Anal Chem* 69:1651
140. Brett CMA, Alves VA, Fungaro DA (2001) *Electroanalysis* 13:212
141. Lam MT, Chakrabarti CL, Cheng J, Pavski V (1997) *Electro-analysis* 9:1018
142. Dalangin RR, Gunasingham H (1994) *Anal Chim Acta* 291:81
143. Murimboh J, Lam MT, Hassan NM, Chakrabarti CL (2000) *Anal Chim Acta* 423:115
144. Buckova M, Vanickova M, Labuda J (1996) *Chem Papers* 50:279
145. Zen JM, Ting YS (1996) *Anal Chim Acta* 332:59
146. Wang J, Deo RP, Thongngamdee S, Ogorevc B (2001) *Electroanalysis* 13:1153
147. Kefala G, Economou A, Voulgaropoulos A (2004) *Analyst* 129:1082
148. Merkoçi A, Vasjari M, Fabregas E et al (2000) *Microchim Acta* 135:29
149. Turyan I, Atiya M, Mandler D (2001) *Electroanalysis* 13:653
150. Chen Z, Pourabedi Z, Hibbert DB (1999) *Electroanalysis* 11:964
151. Li NB, Luo HQ, Chen GN (2004) *Anal sci* 20:825
152. Zen JM, Huang SY (1994) *Anal Chim Acta* 296:77
153. Yang HY, Sun IW (2000) *Electroanalysis* 12:1476
154. Yang HY, Sun IW (1998) *Anal Chim Acta* 358:285
155. Zen JM, Hsu FS, Chi NY et al (1995) *Anal Chim Acta* 310:407
156. Zen JM, Lin HY, Yang HH (2001) *Electroanalysis* 13:505
157. Ugo P, Moretto LM, Mazzocchi GA (1993) *Anal Chim Acta* 273:229

158. Ugo P, Moretto LM, Mazzocchi GA (1995) *Anal Chim Acta* 305:74
159. Ugo P, Zampieri S, Moretto LM, Paolucci D (2001) *Anal Chim Acta* 434:291
160. Yang HY, Chen WY, Sun IW (1999) *Talanta* 50:977
161. Lu TH, Sun IW (1998) *Electroanalysis* 10:1052
162. Lu TH, Huang JF, Sun IW (2002) *Anal Chim Acta* 454:93
163. Yang HY, Sun IW (2000) *Anal Chem* 72:3476
164. Yang HY, Sun IW (1999) *Electroanalysis* 11:195
165. Khoo SB, Zhu J (1998) *Anal Chim Acta* 373:15
166. Ugo P, Sperni L, Moretto LM (1997) *Electroanalysis* 9:1153
167. Arrigan DWM, Lowens MJ (1999) *Electroanalysis* 11:647
168. Yang N, Wan Q, Yu J (2005) *Sens Actuators B* 110:246
169. Hoyer B, Sørensen G, Jensen N et al (1996) *Anal Chem* 68:3840
170. Hoyer B, Sørensen G, Jensen N, Christensen MK (1999) *Electroanalysis* 11:940
171. Zen JM, Wang HF, Kumar AS et al (2002) *Electroanalysis* 14:99
172. Shpigun LK, Lunina VK (2003) *J Anal Chem* 58:1200
173. Shpigun LK, Lunina VK (2003) *J Anal Chem* 58:1097
174. Rahman MA, Won MS, Shim YB (2003) *Anal Chem* 75:1123
175. Rahman MA, Park DS, Won MS et al (2004) *Electroanalysis* 16:1366
176. Turyan I, Erichsen T, Schuhmann W et al (2001) *Electroanalysis* 13:79
177. Zen JM, Wu JW (1996) *Anal Chem* 68:3966
178. Zen JM, Wu JW (1997) *Electroanalysis* 9:302
179. Christensen MK, Hoyer B (2000) *Electroanalysis* 12:35
180. Tsai YC, Davis J, Compton RG et al (2001) *Electroanalysis* 13:7
181. Brett CMA, Fungaro DA (2000) *Talanta* 50:1223
182. Monterroso SCC, Carapuça HM, Duarte AC (2003) *Electroanalysis* 15:1878
183. Mogensen L, Kryger L (1998) *Electroanalysis* 10:1285
184. Monterroso SCC, Carapuça HM, Duarte AC (2005) *Talanta* 65:644
185. Monterroso SCC, Carapuça HM, Duarte AC (2006) *Talanta* 68:1655
186. Lack B, Duncan J, Nyokong T (1999) *Anal Chim Acta* 385:393
187. Yi H (2003) *Anal Bioanal Chem* 377:770
188. Wu K, Hu S, Fei J et al (2003) *Anal Chim Acta* 489:215
189. Sun D, Xie X, Cai Y et al (2007) *Anal Chim Acta* 581:27
190. Gregory XD, Wildgoose G, Compton RG (2006) *Analyst* 131:1241
191. Economou A, Fielden PR (2003) *Analyst* 128:205
192. Ivaska A (1991) *Electroanalysis* 3:247
193. Mandler D, Turyan I (1996) *Electroanalysis* 8:207
194. Gooding J, Mearns F, Yang W et al (2003) *Electroanalysis* 15:81
195. Petrovic SC, Dewald HD (1997) *Anal Chim Acta* 357:33
196. Paneli MG, Voulgaropoulos A (1993) *Electroanalysis* 5:355
197. Abu Zuhri AZ, Voelter W (1998) *Fresenius J Anal Chem* 360:1
198. Zaitsev PM, Salikhzedanova RF, Zaitsev NK (1999) *Zavodsk Lab* 65:1:3
199. Kalcher K (1990) *Electroanalysis* 2:419
200. Ulakhovich NA, Medjantseva EP, Budnikov GK (1993) *J Anal Chem* 48:980
201. Kalcher K, Kauffmann JM, Wang J et al (1995) *Electroanalysis* 7:5
202. Simm AO, Banks CE, Wilkins SJ et al (2005) *Anal Bioanal Chem* 381:979
203. Majid E, Hrapovic S, Liu Y et al (2006) *Anal Chem* 78:762
204. Švancara I, Vytrás K, Bobrowski A, Kalcher K (2002) *Talanta* 58:45
205. Gevorgyan AM, Vanukov VV, Vaznenko SV (2002) *J Anal Chem* 57:301
206. Švancara I, Matoušek M, Sikora E et al (1997) *Electroanalysis* 9:827
207. Flechsig GU, Korbout O, Hocevar SB et al (2002) *Electroanalysis* 14:192
208. Hočevar S, Švancara I, Vytrás K et al (2005) *Electrochim Acta* 51:706
209. Švancara I, Baldrianova L, Tesařová E et al (2006) *Electroanalysis* 18:177
210. Krolicka A, Pauliukaite R, Švancara I et al (2002) *Electrochim Commun* 4:193
211. Pauliukaite R, Metelka R, Švancara I et al (2002) *Anal Bioanal Chem* 374:1155
212. Švancara I, Pravda M, Hvízdalová M et al (1994) *Electroanalysis* 6:663
213. Sherigara BS, Shivaraj Y, Mascarenhas RJ et al (2007) *Electrochim Acta* 52:3137
214. Mascarenhas RJ, Satpati AK, Yellappa S et al (2006) *Anal Sci* 22:871
215. Yoon JH, Muthuraman G, Yang JE et al (2007) *Electroanalysis* 19:1160
216. Shaydarova LG, Ulakhovich NA, El-Gakhri MA et al (1995) *J Anal Chem* 50:755
217. Ulakhovich NA, El-Gakhri MA, Shaydarova LG et al (1994) *Zavodsk Lab* 60/3:14
218. Shaydarova LG, Ulakhovich NA, Fedorova IL et al (1996) *J Anal Chem* 51:746
219. Shaydarova LG, El-Gakhri MA, Ulakhovich NA et al (1994) *J Anal Chem* 49:501
220. Ijeri VS, Srivastava AK (2000) *Fresenius J Anal Chem* 367:373
221. Tanaka S, Yoshida H (1989) *Talanta* 36:1044
222. Canpolat EÇ, Sar E, Coşkun NY et al (2007) *Electroanalysis* 19:1109
223. Roa-Morales G, Ramírez-Silva MT, González RL et al (2005) *Electroanalysis* 17:694
224. Roa-Morales G, Ramírez-Silva MT, Romero-Romo MA et al (2003) *Anal Bioanal Chem* 377:763
225. Roa-Morales G, Ramírez-Silva MT, González RL et al (2003) *J of Solid State Electrochemistry* 7:355
226. Alpat SK, Yuksel U, Akcay H (2005) *Electrochim commun* 7:130
227. Walcarius A, Mariaulle P, Lamberts L (2003) *J of Solid State Electrochemistry* 7:671
228. Walkarius A, Despas C, Bessiere J (1999) *Anal Chim Acta* 385:79
229. Walkarius A, Bessiere J (1997) *Electroanalysis* 9:707
230. Walcarius A, Devoy J, Bessiere J (2000) *J. of Solid State Electrochemistry* 4:1433
231. Etienne M, Bessiere J, Walcarius A (2001) *Sens Actuators* 76:531
232. Filho NLD, Carmo DR, Rosa AH (2006) *Electrochim Acta* 52:965
233. Takeuchi RM, Santos A, Padilha PM et al (2007) *Talanta* 71:771
234. Takeuchi RM, Santos A, Padilha PM et al (2007) *Anal Chim Acta* 584:295
235. Marino G, Bergamini MF, Teixeira MS et al (2003) *Talanta* 59:1021
236. Aleixo LM, Souza MFB, Godinho OES et al (1993) *Anal Chim Acta* 271:143
237. Filho NLD, Carmo DR, Caetano L et al (2005) *Anal Sci* 21:1359
238. Yantasee W, Lin Y, Zemanian TS et al (2003) *Analyst* 128:467
239. Sayen S, Etienne M, Bessiere J et al (2002) *Electroanalysis* 14:1521
240. Yantasee W, Lin Y, Fryxell GE et al (2004) *Electroanalysis* 16:870
241. Yantasee W, Lin Y, Fryxell GE et al (2004) *Anal Chim Acta* 502:207
242. Bond AM, Miao W, Smith TD et al (1999) *Anal Chim Acta* 396:203
243. Shams E, Torabi R (2006) *Sens Actuators B* 117:86
244. Ogorevc B, Cai X, Grabec I (1995) *Anal Chim Acta* 305:176
245. Svegl IG, Ogorevc B, Hudnik V (1996) *Fresenius J Anal Chem* 354:770

246. Kalcher K, Grabec I, Raber G et al (1995) *J Electroanal Chem* 386:149
247. Švegl IG, Kolar M, Ogorevc B et al (1998) *Fresenius J Anal Chem* 361:358
248. Kula P, Navratilova Z (1996) *Fresenius J Anal Chem* 354:692
249. Huang W (2004) *Microchim Acta* 144:125
250. Huang W, Yang C, Zhang S (2002) *Anal Bioanal Chem* 374:998
251. Kula P, Navratilova Z, Kulova P et al (1999) *Anal Chim Acta* 385:91
252. Wang J, Martinez T (1989) *Electroanalysis* 1:167
253. Filho NLD, Carmo DRC, Gessner F et al (2005) *Anal sci* 21:1309
254. Wang J, Greene B, Morgan C (1984) *Anal Chim Acta* 158:15
255. Labuda J, Korgová H, Vaníčková M (1995) *Anal Chim Acta* 305:42
256. Agraz R, Sevilla MT, Pinilla JM et al (1991) *Electroanalysis* 3:393
257. Agraz R, Sevilia MT, Hernandez L (1995) *J Electroanalytical Chemistry* 390:47
258. Helms I, Scholz F (1996) *Fresenius J Anal Chem* 356:237
259. Sun Q, Wang C, Li L et al (1999) *Fresenius J Anal Chem* 363:114
260. Jeong ED, Won MS, Sbim YB (1994) *Electroanalysis* 6:887
261. Wang C, Zhang H, Sun Y et al (1998) *Anal Chim Acta* 361:133
262. Wang C, Li H (1998) *Electroanalysis* 10:44
263. Švegl IG, Ogorevc B (2000) *Fresenius J Anal Chem* 367:701
264. Švancara I, Kalcher K, Diewald W et al (1996) *Electroanalysis* 8:336
265. Lubert KH, Beyer L, Casabo J et al (1998) *Electroanalysis* 10:860
266. Guo H, Li Y, Xiao P et al (2005) *Anal Chim Acta* 534:143
267. Liu N, Song JF (2005) *Anal Bioanal Chem* 383:358
268. Ju-nan L, Jun Z, Pei-hong D et al (2001) *Analyst* 126:2032
269. Liu S, Li J, Zhang S et al (2005) *Applied Surface Science* 252:2078
270. Stadlober M, Kalcher K, Raber G (1997) *Sci Pap Univ Pardubice Ser A* 3:103
271. Stadlober M, Kalcher K, Raber G (1997) *Anal Chim Acta* 350:319
272. Švancara I, Galik M, Vytras K (2006) *Talanta* 72:512
273. Galik M, cholota M, Švancara I et al (2006) *Electroanalysis* 18:2218
274. Bai ZP, Nakamura T, Izutsu K (1990) *Electroanalysis* 2:75
275. Ferri T, Guidi F, Morabito R (1994) *Electroanalysis* 6:1087
276. Raber G, Kalcher K, Neuhold CG et al (1995) *Electroanalysis* 7:138
277. Gurentsova OI, Prokhorova GV, Osipova EA (1992) *J Anal Chem* 47:1671
278. Prokhorova GV, Osipova EA, Gurentsova OI (1993) *J Anal Chem* 48:1621
279. Osipova EA, Prokhorova GV, Gurentsova OI (1994) *Zavodsk Lab* 60/2:5
280. Osipova EA, Kamenev AI, Sladkov VE et al (1997) *J Anal Chem* 52:273
281. Osipova EA, Sladkov VE, Kamenev AI et al (2000) *Anal Chim Acta* 404:231
282. Osipova EA, Sladkov VE, Shkinev VM (2000) *J Anal Chem* 55:844
283. Sladkov VE, Osipova EA (2001) *J Anal Chem* 56:52
284. Yabutani T, Utsunomiya Y, Kado Y et al (2006) *Anal sci* 22:1021
285. Cai Q, Khoo SB (1995) *Electroanalysis* 7:379
286. Khoo SB, Guo SX (1999) *J Electroanal Chem* 465:102
287. Khodari M, Krishna MMA, Fandy R (1994) *Talanta* 41:2179
288. Fanta K, Chandravanshi BS (2001) *Electroanalysis* 13:484
289. Degefa TH, Chandravanshi BS, Alemu H (1999) *Electroanalysis* 11:1305
290. Refera T, Chandravanshi BS, Alemu H (1998) *Electroanalysis* 10:1038
291. Molina-Holgado T, Pinilla-Macias JM, Hernandez-Hernandez L (1995) *Anal Chim Acta* 309:117
292. Ruiperez J, Mendiola MA, Sevilla MT et al (2002) *Electroanalysis* 14:532
293. Colilla M, Mendiola MA, Procopio JR et al (2005) *Electroanalysis* 17:933
294. Hernandez E, Naranjo-Rodriguez I, Hidalgo-Hidalgo de Cisneros JL (2007) *Sens Actuators B* 123:488
295. Navratilova Z (1991) *Electroanalysis* 3:799
296. Prabhu SV, Baldwin RP (1987) *Anal Chem* 59:1074
297. Gao Z, Li P, Wang G et al (1990) *Anal Chim Acta* 241:137
298. Hu C, Wu K, Dai X et al (2003) *Talanta* 60:17
299. Khoo SB, Soh MK, Cai Q et al (1997) *Electroanalysis* 9:45
300. Lu X, Wang Z, Geng Z et al (2000) *Talanta* 52:411
301. Guttmann M, Beyer KHL (1996) *Fresenius J Anal Chem* 356:263
302. Agraz R, Miguel J, Sevilla MT et al (1996) *Electroanalysis* 8:565
303. Peng T, Shen L, Wang G (1996) *Microchimica Acta* 122:125
304. Woon MS, Moon DW, Shim YB (1995) *Electroanalysis* 7:1171
305. Khoo SB, Zhu J (1996) *Analyst* 121:1983
306. Adraoui I, Rhazi ME, Amine A et al (2005) *Electroanalysis* 17:685
307. Khoo SB, Cai Q (1996) *Electroanalysis* 8:549
308. Zhang ZQ, Liu H, Zhang H et al (1996) *Anal Chim Acta* 333:119
309. Kurbatov DI, Bulgakova L (1996) *J Anal Chem* 51:410
310. Liu S, Li J, Mao X (2003) *Electroanalysis* 15:1751
311. Connor M, Dempsey E, Smyth MR et al (1991) *Electroanalysis* 3:331
312. Ramos JA, Bermejo E, Zapardiel A et al (1993) *Anal Chim Acta* 273:219
313. Brainina Kh, Neyman E (1993) *Electroanalytical stripping methods*. Wiley, New York
314. Brainina Kh, Khodos M, Belisheva G, Vidrevich M (1990) *Zeitschrift Fur Physikalisch Chemie Neue Folge* 168:65
315. Gruner W, Stablberg R, Brainina Kh, Akselrod N, Kamyshov V (1990) *Electroanalysis* 2:397
316. Ulakhovich NA, Medjantseva EP, Mashkina SV (1997) *J Anal Chem* 52:373
317. Domenech-Carbo A, Domenech-Carbo MT, Gimeno-Adelantado JV et al (2000) *Electroanalysis* 12:120
318. Fetisov VB, Ermakov AN, Belysheva GM, Fetisov AV, Kamyshov VM, Brainina KHZ (2004) *J Solid State Electrochem* 8:565
319. Grygar T, Marken F, Schröder U, Scholz F (2002) *Collect Czech Chem Commun* 67:163